

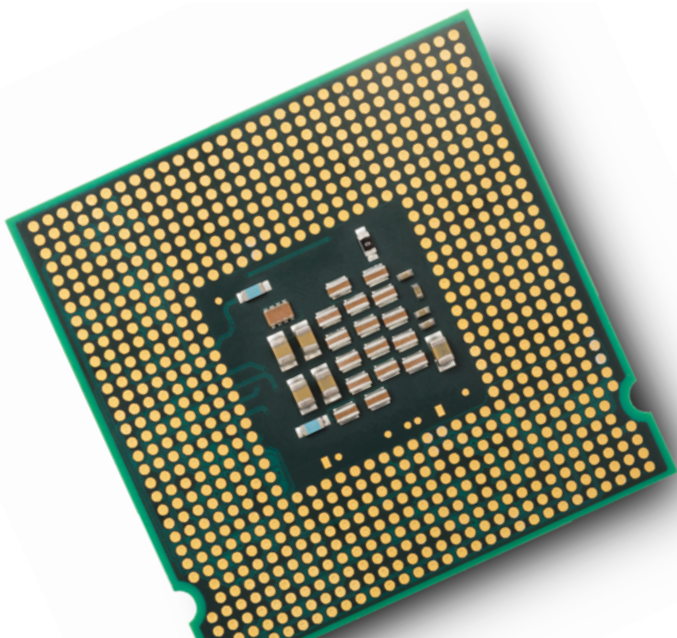
Solutions for the Semiconductor Industry



WHO WE ARE, WHAT WE DO.

We are scientists, engineers, thinkers, technologists, collaborators, and creators who understand critical details in materials technology.

Greene Tweed solutions deliver proven performance for leading semiconductor fabs, foundries, and OEMs.



Unparalleled Performance for Semiconductor Fabrication

Greene Tweed remains an innovator, keeping pace with the explosive advancements of the semiconductor industry. Chemraz® seals withstand the plasmas used in cutting-edge deposition and etch wafer processing. ONX® 600 composite components resist harsh chemicals used in semiconductor manufacturing. Our expert solutions include bonding, encapsulation, and coating capabilities for extra protection.

In addition to designing seals and composites that enable the manufacture of chips to power next-generation mobile devices, we also create:

Landing gear seals relied upon in 80%+ of commercial aircraft

Elastomeric seals which withstand 35,000+ pound per square inch (PSI) under 3 miles of ocean in deep water oil & gas wells

Composite wear parts that increase pump reliability to keep oil refineries running

Custom-designed structural components that reduce aircraft weight to improve fuel efficiency

Electrical and fiber optic connectors which reliably transmit signals in the harshest environments

1,900 employees across 11 countries support the most advanced global companies.

GREENE TWEED OVERVIEW

SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

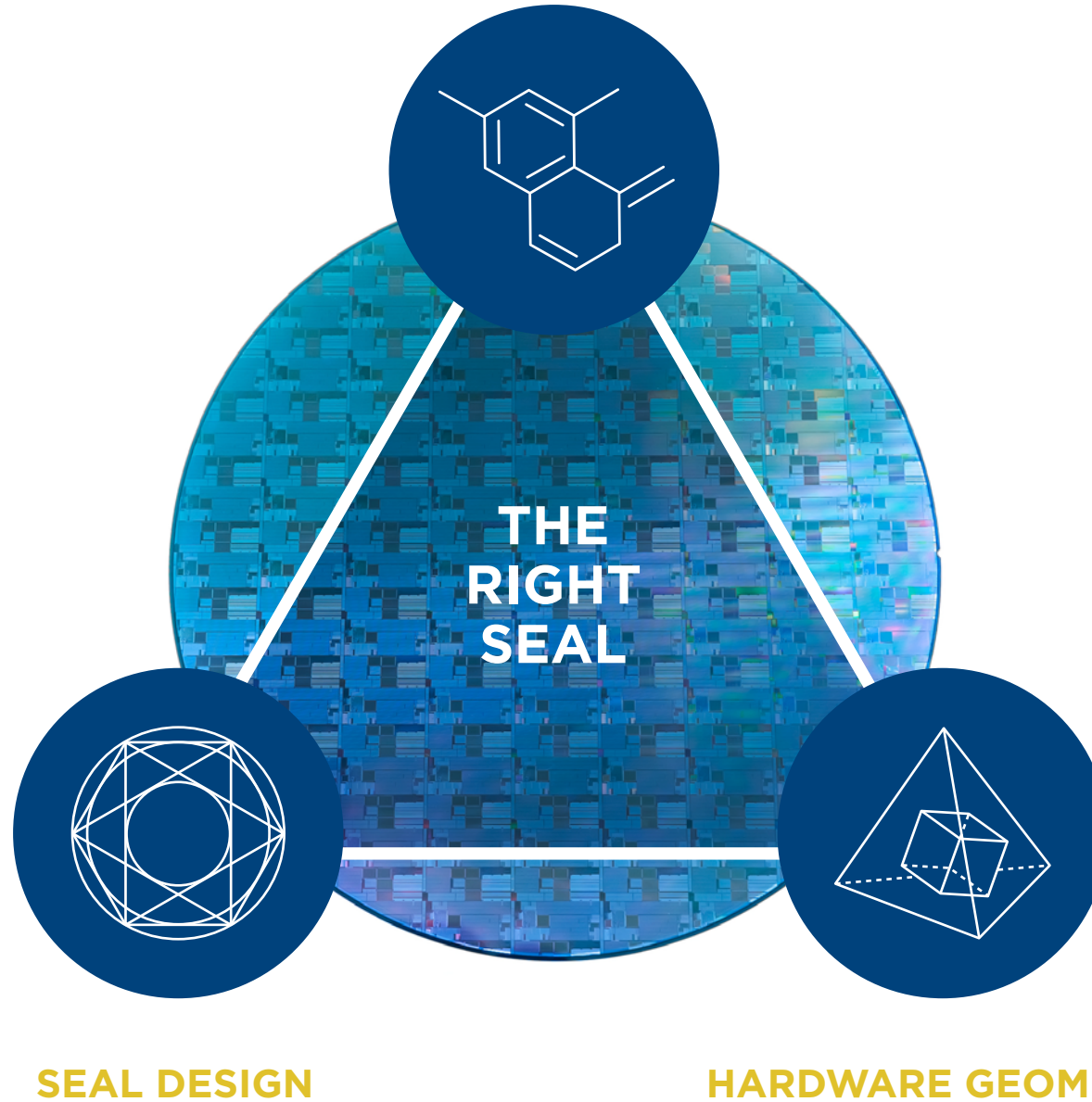
Chemical Compatibility Guide

WHO WE ARE, WHAT WE DO.

Greene Tweed sealing solutions are built to resist the industry's harshest chemicals and most extreme temperatures.

No matter how demanding the environment or niche the application, Greene Tweed offers customizable, high-performance sealing solutions in both industry standard and non-standard sizes and materials.

SEALING COMPOUND



SEAL DESIGN

HARDWARE GEOMETRY

GREENE TWEED OVERVIEW

SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

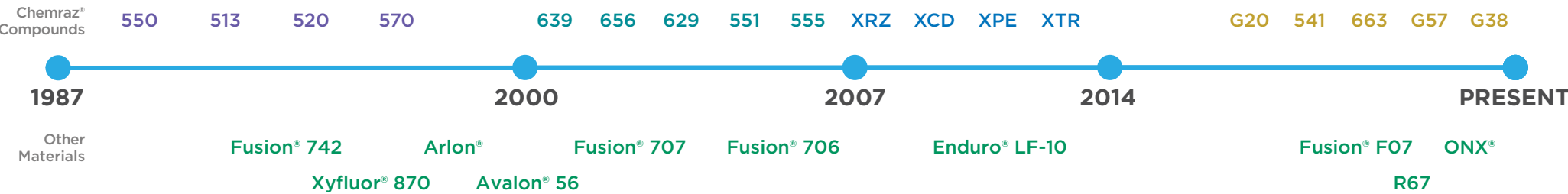
SubFab

ADDITIONAL RESOURCES

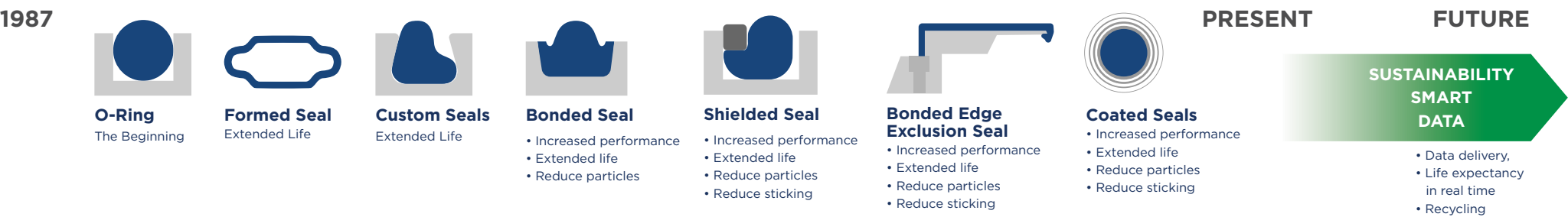
Seal Handling Training

Chemical Compatibility Guide

Semiconductor Materials



Seal Design



ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Semiconductor – Moore’s Law



Moore’s Law – Decreasing Transistor Size

As Moore’s Law has created extreme challenges in the Semiconductor Industry, GT has come along side our customers and developed innovative materials and designs that have met our customer’s needs. We continue to do it today. Come and let Greene Tweed help you enable your processes.

WHY GREENE TWEED?

Greene Tweed designs and manufactures components, materials, and solutions that perform in the harshest environments. We engineer for conditions where equipment failure is not an option. Our products are made for extreme temperatures, pressure, chemical corrosion, and mechanical wear.



GREENE TWEED OVERVIEW

SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

MARKETS WE SERVE

Greene Tweed enables customers to operate efficiently and safely in the world's most demanding environments. We design, manufacture, and deliver innovative products with trusted performance for markets where failure is not an option.



GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

PRODUCTS
WE MANUFACTURE

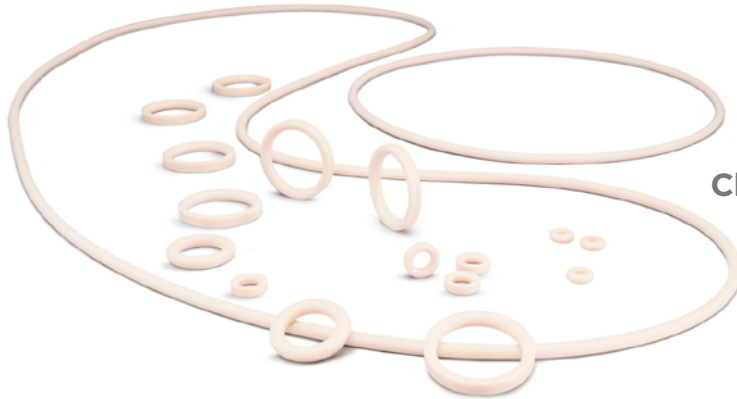
Sealing Solutions



Structural
Components



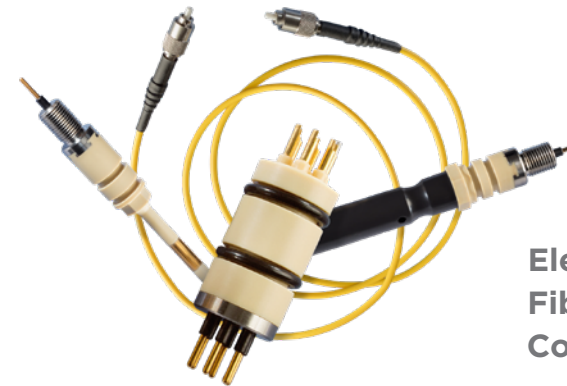
Chemraz®



Engineered Wear
Components



Electrical &
Fiber Optic
Connectors



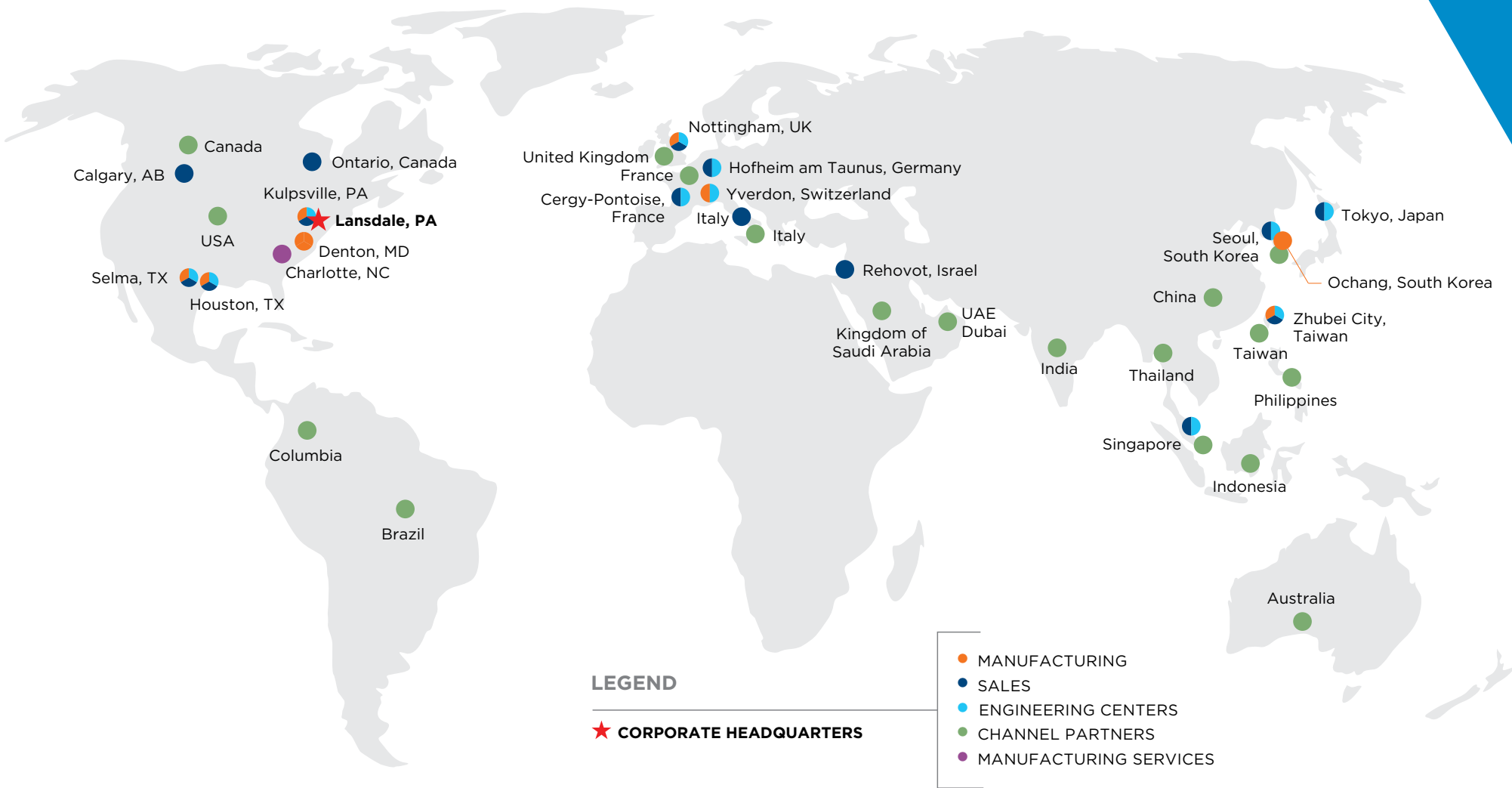
ADDITIONAL
RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

Global Presence with Local Support – 1,900 Employees Across 11 Countries

WHERE WE ARE



ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

MANUFACTURING

Facilities

United Kingdom, United States,
Switzerland, Taiwan, Korea

Certifications

ISO 9001:2015
ISO/IEC 17025:2017
ISO 14001:2015
AS9100:2016
EN9100:2018

Cleanrooms

Class 100 & 1000

**Compression and injection
molding capabilities**

Materials Lab

Quality control of raw materials

Plasma Lab

Semiconductor parts testing using
process gases

Accredited Testing Lab

ISO/IEC 17025:2017

Product Testing Lab

Pump wear rig, landing gear rig,
sealing pressure vessel test rig,
structural composites testing

**Finite Elements Analysis
(FEA)**



GREENE TWEED OVERVIEW

SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

CHAMBER SOLUTIONS

When purity is a must, Greene Tweed offers a range of solutions for the dry etch vacuum environment.

Expert Innovation

Greene Tweed sealing solutions combat the harsh plasmas and chemicals in wafer fabrication processes, resisting wear and tear from cleaning, patterning, and deposition.



GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

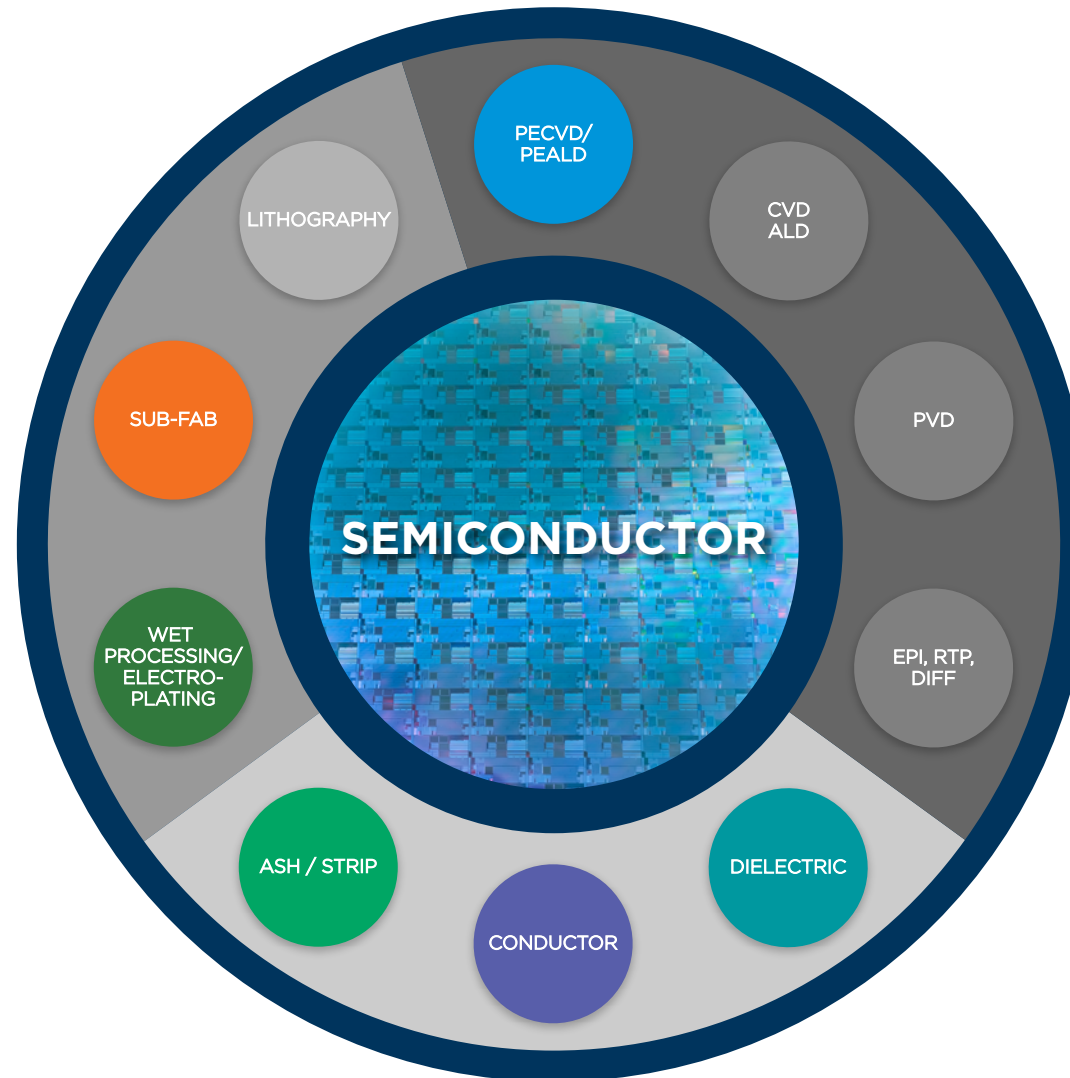
ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

SOLUTIONS BY PROCESS AREA

Explore the various solutions Greene Tweed offers for each process area.



Click on the colored circles to jump to the solutions for those process areas.

The process areas indicated as gray circles will be activated in future versions of this guide.

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

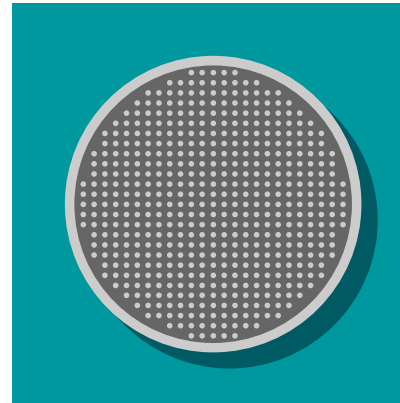
In dielectric etch tools, seals are typically used in chambers, gas entry/exhaust ports, chamber doors, and wafer chucks. Protection against oxygen-infused plasma is key in many etch chamber environments, which often break down non-resistant materials and cause harmful particulation, resulting in defective chips.

DIELECTRIC ETCH SOLUTIONS

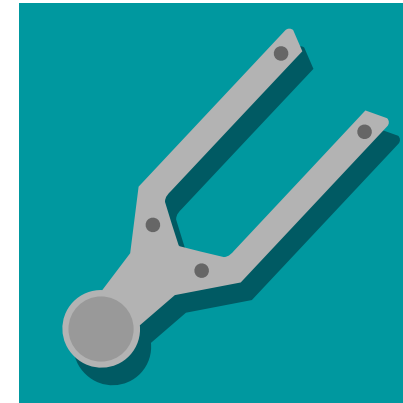
Our seals offer superior chemical resistance, minimal particle generation in plasma, and long service life to minimize maintenance and downtime.



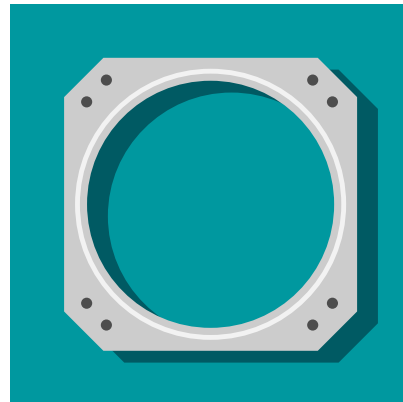
Slit Valve Solutions



Electrostatic Chuck (ESC) Solutions



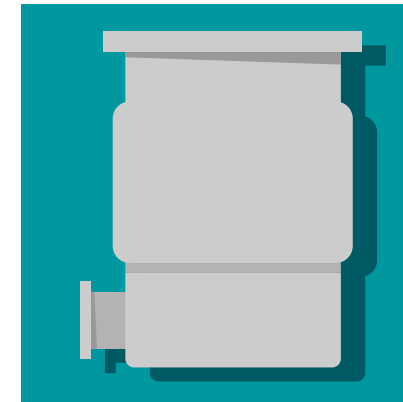
End Effector Solutions



Chamber Seal Solutions



Pendulum Valve Solutions



Turbomolecular Pump Solutions

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

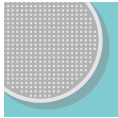
Slit Valve Solutions

The Shielded-Bonded Slit Valve Door (SBSV) and Bonded Slit Valve Door (BSV) significantly increase the life expectancy and performance of the door's seal during semiconductor plasma processing. Made from Greene Tweed's proprietary high-purity PTFE compound, Avalon® 56 HP, the SBSV shield enhances our unique BSV (Bonded Slit Valve) door design.

DIELECTRIC ETCH SOLUTIONS



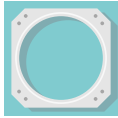
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



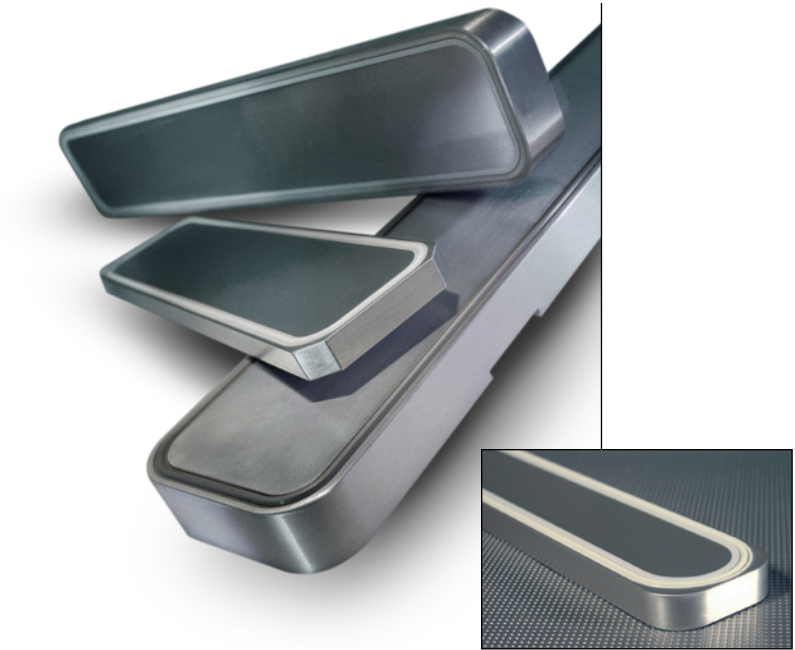
Chamber Seal Solutions



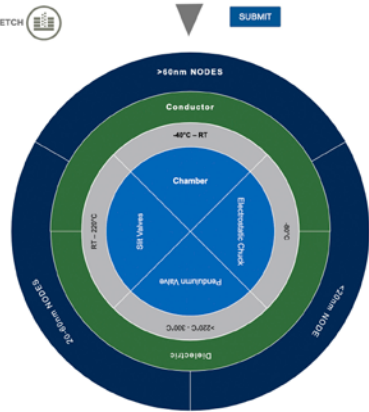
Pendulum Valve Solutions



Turbomolecular Pump Solutions



Bonded Slit Valve (BSV) Doors and Shielded-Bonded Slit Valve (SBSV) Door (inset)



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

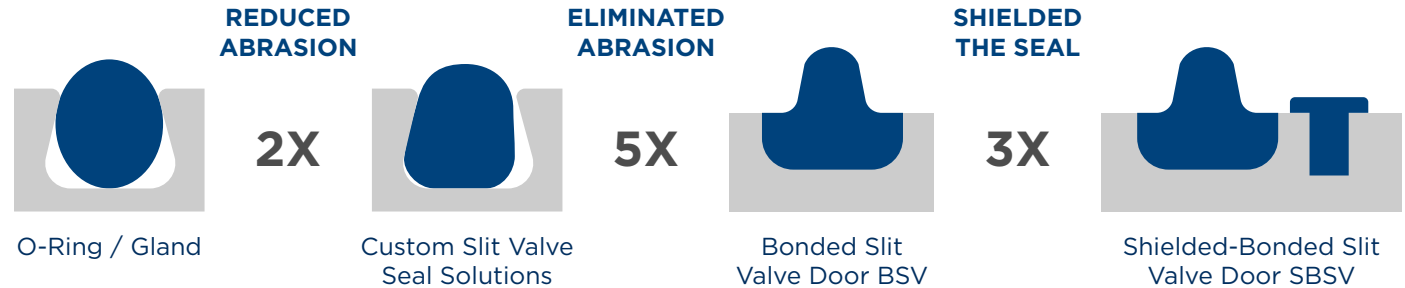
Chemraz® G57 | Chemraz® XPE | Chemraz® 629
Chemraz® E38 | Chemraz® G38

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

SEAL DESIGN EVOLUTION



Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

Electrostatic Chuck (ESC) Solutions

E-seal refers to the electrostatic chuck seal application. Made from Greene Tweed’s proprietary high-purity Chemraz® elastomers and Avalon® 56 HP PTFE fluoroplastics compounds, the e-seal significantly increases the life expectancy of the electrostatic chuck by protecting the outside diameter of the chuck from plasma erosion. To enable extreme cooling of the e-chuck, Greene Tweed provides custom MSE cryogenic seals that seal down to -150°C. Chemraz® 663 allows sealing down to -40°C.

DIELECTRIC ETCH SOLUTIONS



Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



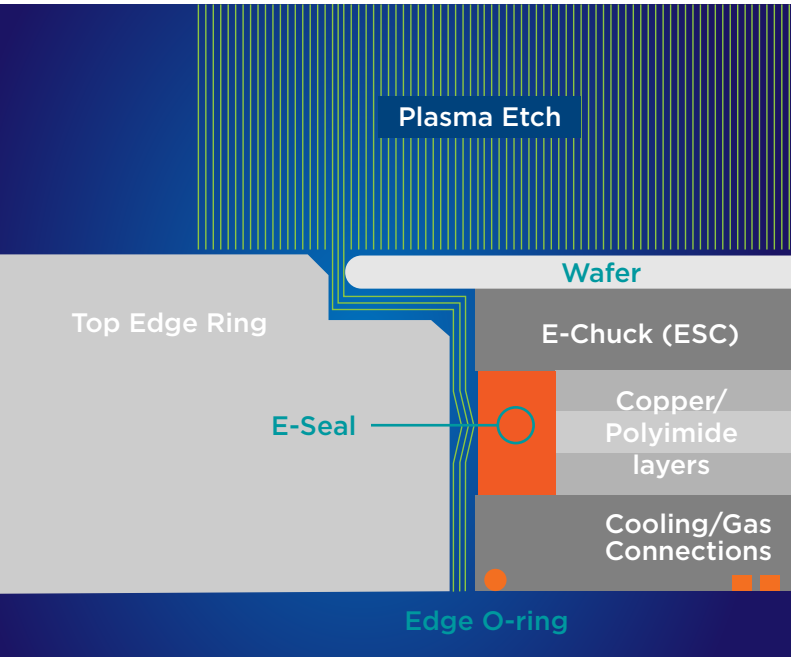
Chamber Seal Solutions



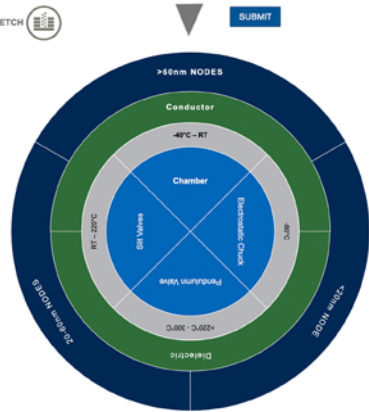
Pendulum Valve Solutions



Turbomolecular Pump Solutions



E-Seal solution to protect the E-Chuck



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® XPE | Chemraz® 663 | Avalon® 56 HP
MSE® Cryogenic | Chemraz® 629

SEAL DESIGN SOLUTIONS Small cross-sections, critical, high-precision



O-Ring
(All Glands)



Elastomer
(All Glands)



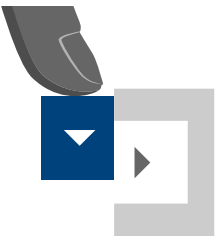
Plastic
(All Glands)



Plastic Encapsulated
O-ring
(All Glands)



MSE (low temp)
(All Glands)



Installation
Fixtures

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Related Videos

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

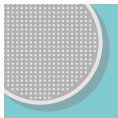
Wafer Transfer Robot End-Effector Solutions

Greene Tweed offers end effector solutions (wafer handling/robot blade applications) including o-rings. Greene Tweed provides custom Chemraz® elastomer and Arlon® high-temperature thermoplastic solutions. A combination of material performance and engineering design optimizes wafer handling. This enhances slip resistance, wear resistance, and low sticking properties.

DIELECTRIC ETCH SOLUTIONS



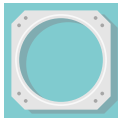
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



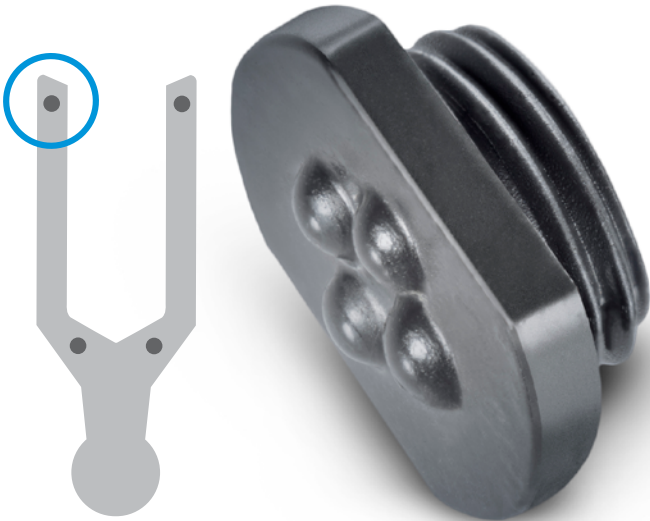
Chamber Seal Solutions



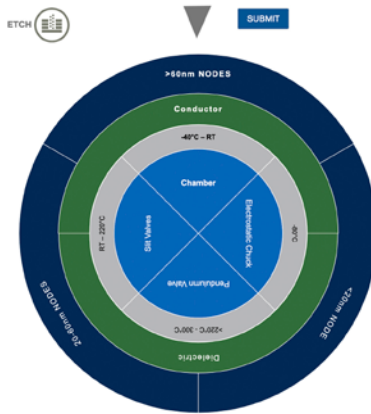
Pendulum Valve Solutions



Turbomolecular Pump Solutions



Arlon 3000XT® End-effector pad

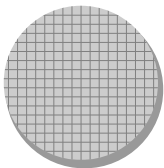


Click on the Elastomer Selection Wheel to explore other Chemraz® material options

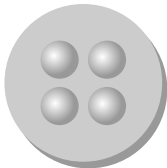
Click on the compound for more information.

Chemraz® XCD | Arlon® | Arlon 3000XT®

DESIGN SOLUTIONS



Custom Surface Finishes



Custom Surface Design



Extremely Small O-rings



Custom Bonded Designs



Custom Elastomer Pad Designs



Custom Plastic Pad Designs

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

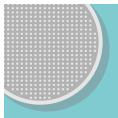
Chamber Seal Solutions

Chemraz® seals provide excellent performance in plasma etch process chambers. In particular they are compatible with fluorine and oxygen plasmas and are less susceptible to cracking. Seal design also needs to be considered to optimize seal performance.

DIELECTRIC ETCH SOLUTIONS



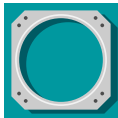
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



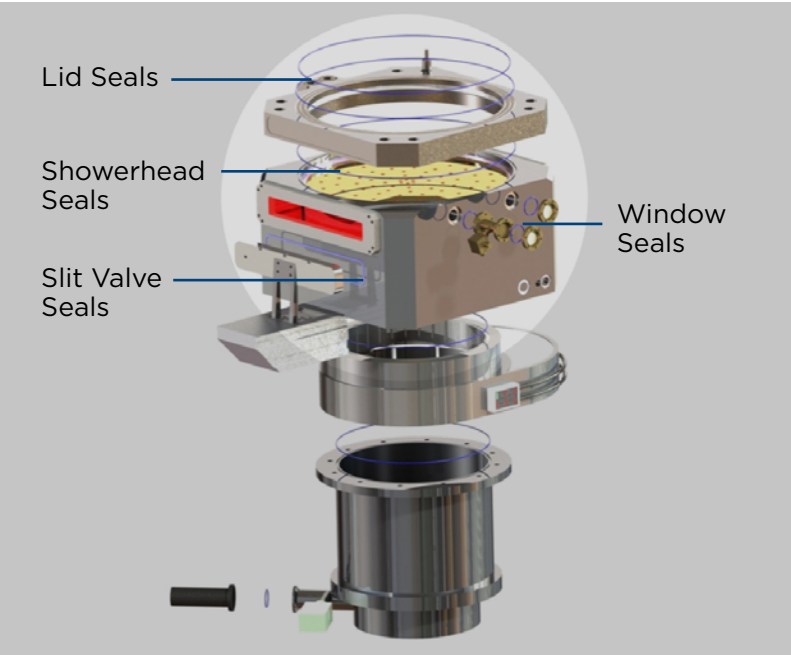
Chamber Seal Solutions



Pendulum Valve Solutions



Turbomolecular Pump Solutions



Typical process chamber.

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



Dovetail Seal
(Dovetail Gland)



Glandlock® Seal
(Half Dovetail Gland)



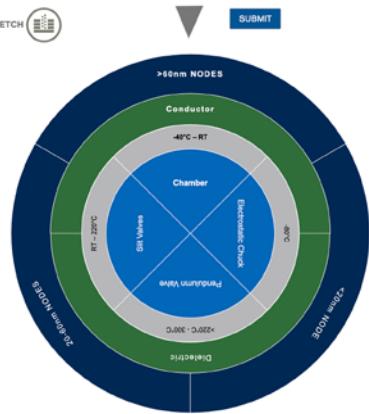
Formed Seal



Barrel Seal
(All Glands)



Shielded Seal
(All Glands)



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® G57 | Chemraz® XPE | Chemraz® XCD
Chemraz® 629 | Chemraz® E38 | Chemraz® G38

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

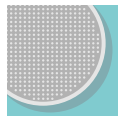
Pendulum Valve Solutions

Our pendulum valve solutions significantly increase the life expectancy and performance of the gate valves during semiconductor plasma processing. These solutions are designed to eliminate premature failures caused by chemical and mechanical degradation.

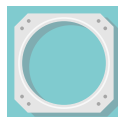
DIELECTRIC ETCH SOLUTIONS



Slit Valve Solutions

Electrostatic
Chuck
Solutions

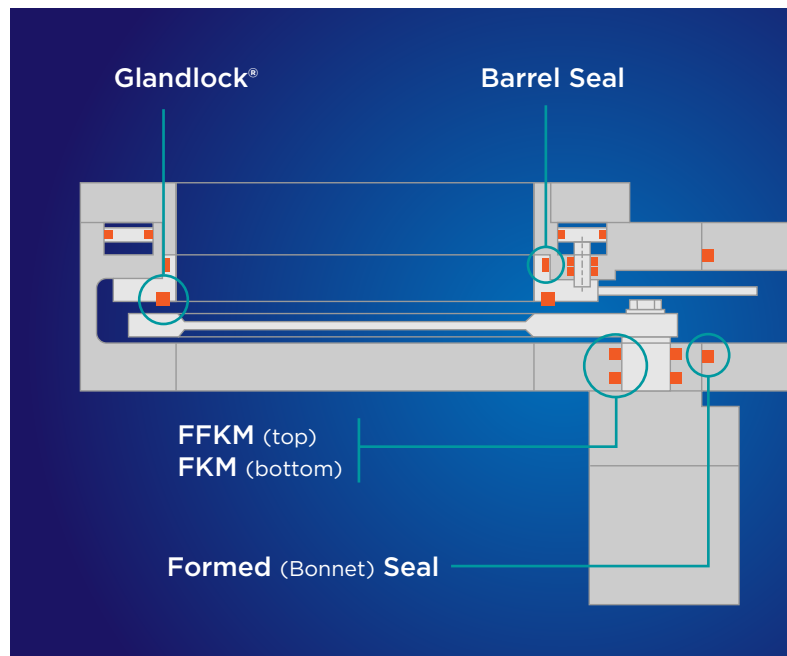
End Effector Solutions

Chamber Seal
Solutions

Pendulum Valve Solutions



Turbomolecular
Pump
Solutions



Seal placement in the pendulum valve.



Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

Click on the compound for more information.

Chemraz® G57 | Chemraz® G38 | Chemraz® XCD
Chemraz® 629 | Chemraz® E38 | Enduro® LF10

SEAL DESIGN SOLUTIONS



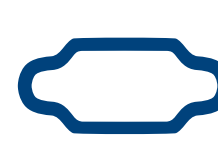
O-Ring (Dynamic Actuator)



Glandlock® Seal (Plate)



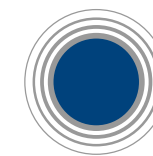
Barrel Seal (Body)



Formed Seal
(Bonnet)



Bonded Seal (Paddle)



Coated Seals (Dynamic Actuator)

GREENE TWEED OVERVIEW

SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed
sealing solutions engineer
to learn how we can help solve
your application concerns.

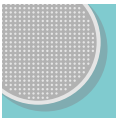
Turbomolecular Pump Solutions

Chemraz® and Fusion® solutions can be used in turbomolecular pump applications up to 300°C and are compatible with deposition and etch process gases such as fluorine and oxygen. The combination elastomer material and seal design provides solutions that are less susceptible to cracking and overfill.

DIELECTRIC ETCH SOLUTIONS



Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



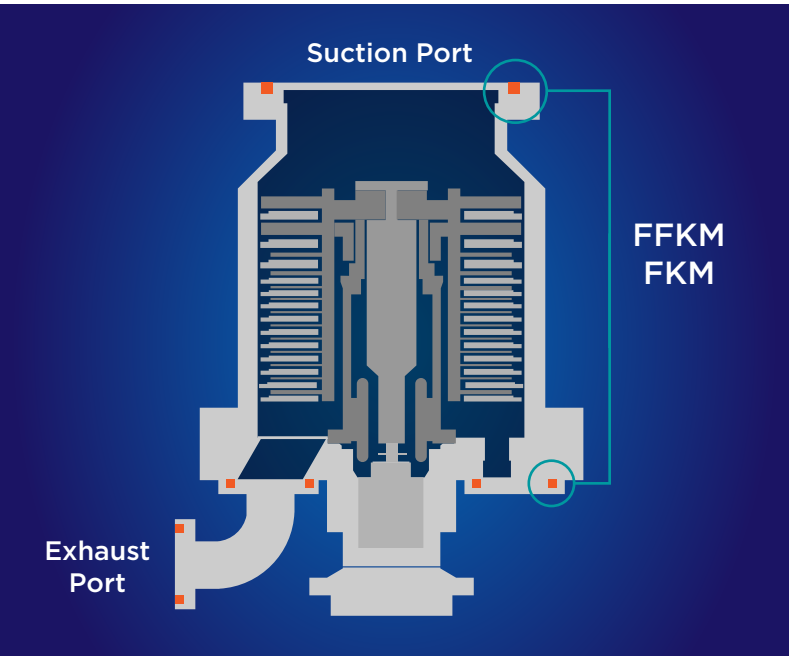
Chamber Seal Solutions



Pendulum Valve Solutions



Turbomolecular Pump Solutions



Seal locations on a turbomolecular pump

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



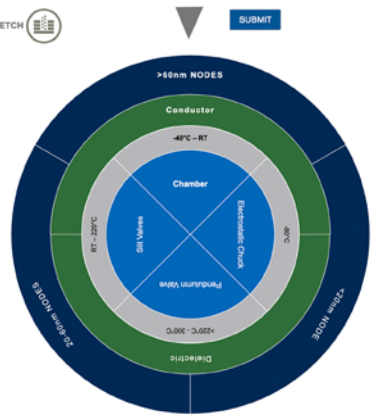
Custom Seal Design
(Glandlock® Seal)



Custom Design Seal
(Barrel Seal)



O-ring Kits



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® G57

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

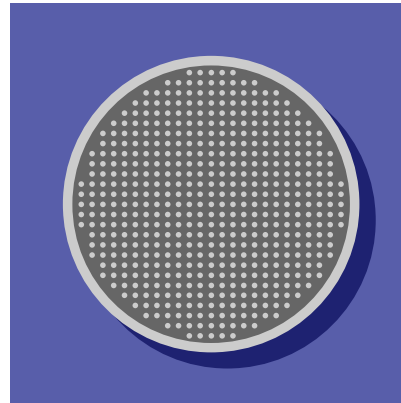
In conductor etch tools, seals are typically used in chambers, gas entry/exhaust ports, chamber doors, and wafer chucks. Protection against oxygen and fluorine infused plasma is key in many etch chamber environments, which often break down non-resistant materials and cause harmful particulation, resulting in defective chips.

CONDUCTOR ETCH SOLUTIONS

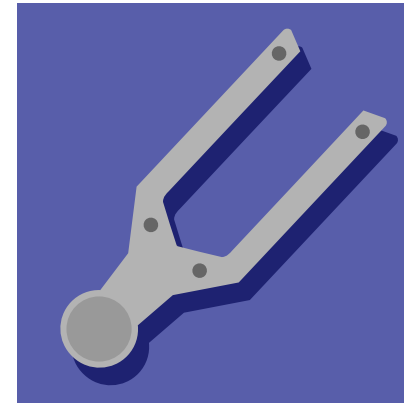
Our seals offer superior chemical resistance, minimal particle generation in plasma, and long service life to minimize maintenance and downtime.



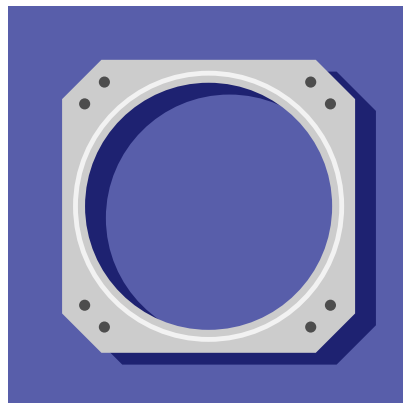
Slit Valve Solutions



E-Seal Solutions



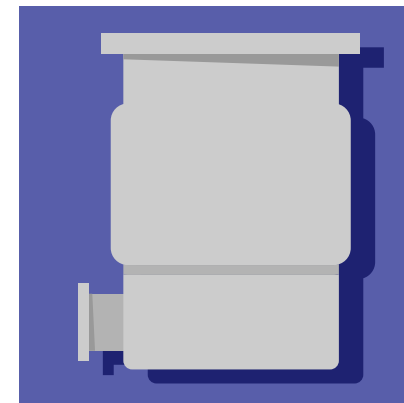
End Effector Solutions



Chamber Seal Solutions



Pendulum Valve Solutions



Turbomolecular Pump Solutions

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

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SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

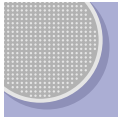
Slit Valve Solutions

The Shielded-Bonded Slit Valve Door (SBSV) and Bonded Slit Valve Door (BSV) significantly increase the life expectancy and performance of the door's seal during semiconductor plasma processing. Made from Greene Tweed's proprietary high-purity PTFE compound, Avalon® 56 HP, the SBSV shield enhances our unique BSV (Bonded Slit Valve) door design.

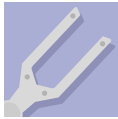
CONDUCTOR ETCH SOLUTIONS



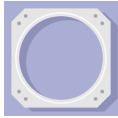
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



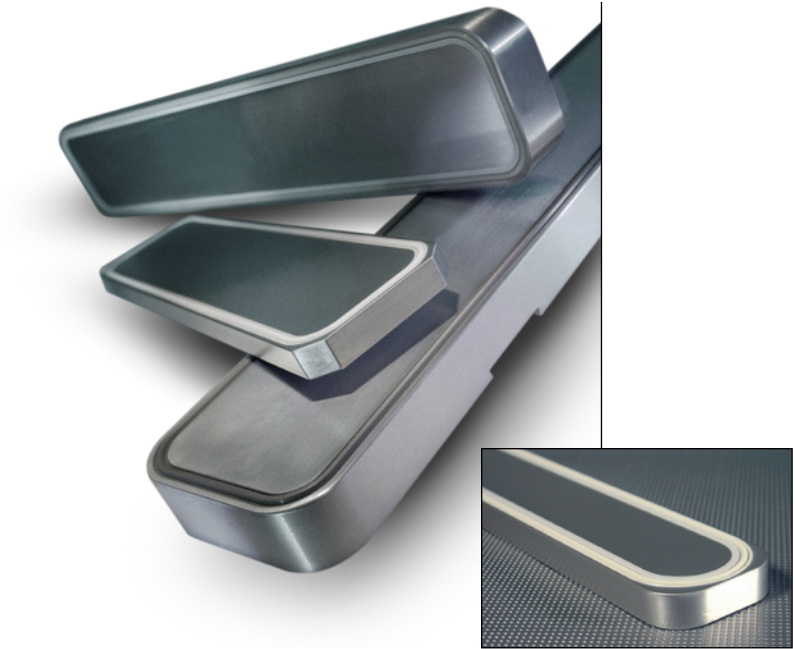
Chamber Seal Solutions



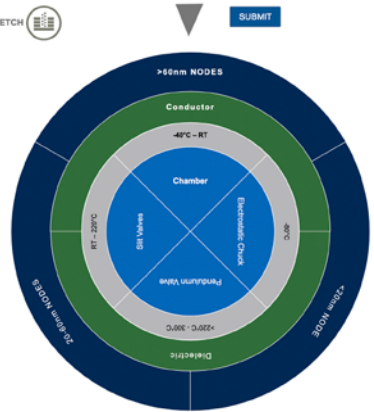
Pendulum Valve Solutions



Turbomolecular Pump Solutions



Bonded Slit Valve (BSV) Doors and Shielded-Bonded Slit Valve (SBSV) Door (inset)



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

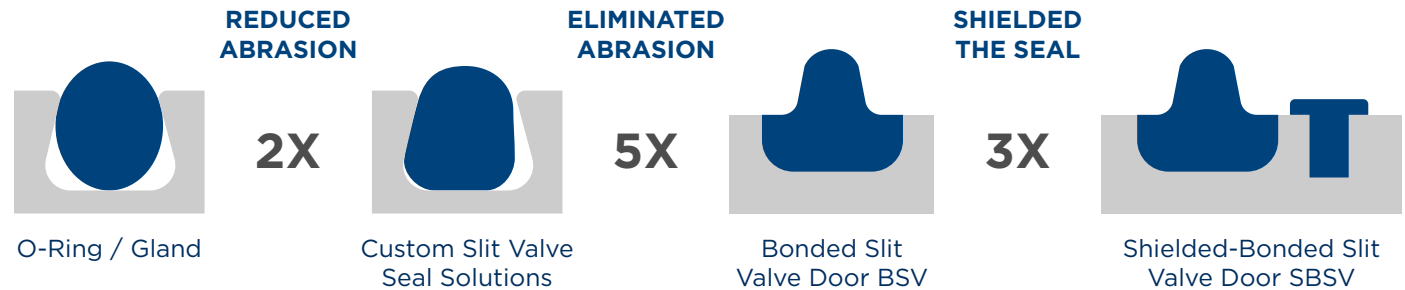
Chemraz® G57 | Chemraz® XPE | Chemraz® 629
Chemraz® E38 | Chemraz® G38

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

SEAL DESIGN EVOLUTION



Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

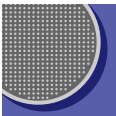
Electrostatic Chuck (ESC) Solutions

E-seal refers to the electrostatic chuck seal application. Made from Greene Tweed’s proprietary high-purity Chemraz® elastomers and Avalon® 56 HP PTFE fluoroplastics compounds, the e-seal significantly increases the life expectancy of the electrostatic chuck by protecting the outside diameter of the chuck from plasma erosion. To enable extreme cooling of the e-chuck, Greene Tweed provides custom MSE cryogenic seals that seal down to -150°C. Chemraz® 663 allows sealing down to -40°C.

CONDUCTOR ETCH SOLUTIONS



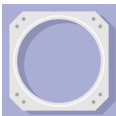
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



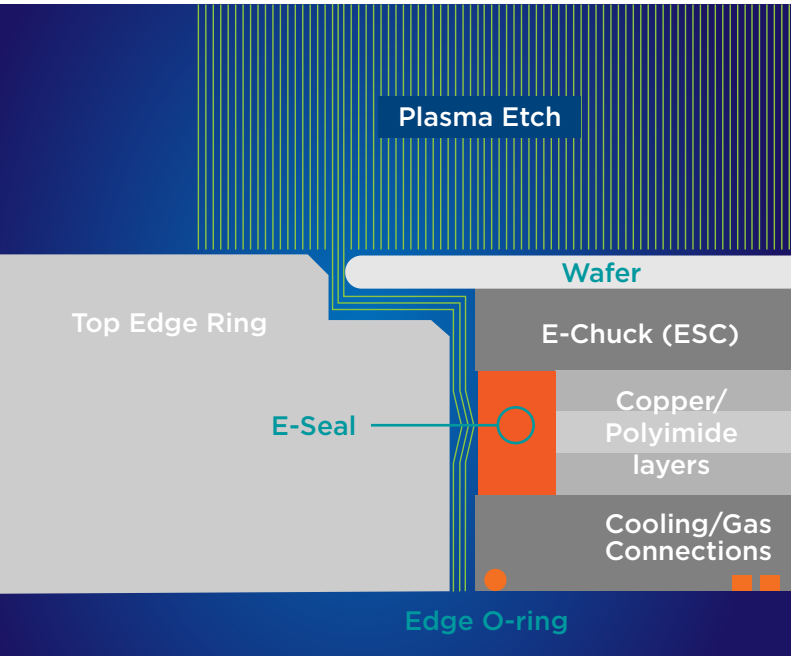
Chamber Seal Solutions



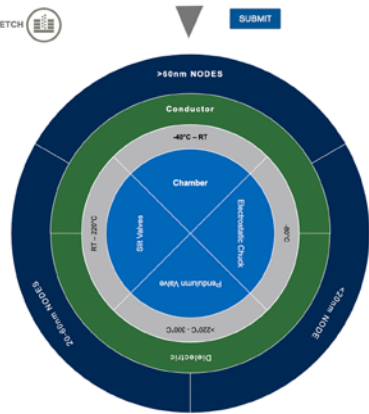
Pendulum Valve Solutions



Turbomolecular Pump Solutions



E-Seal solution to protect the E-Chuck



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® XPE | Chemraz® 663 | Avalon® 56 HP
MSE® Cryogenic | Chemraz® 629

SEAL DESIGN SOLUTIONS Small cross-sections, critical, high-precision



O-Ring
(All Glands)



Elastomer
(All Glands)



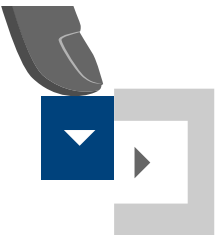
Plastic
(All Glands)



Plastic Encapsulated
O-ring
(All Glands)



MSE (low temp)
(All Glands)



Installation
Fixtures

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Related Videos

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

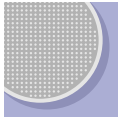
Wafer Transfer Robot End-Effector Solutions

Greene Tweed offers end effector solutions (wafer handling/robot blade applications) including o-rings. Greene Tweed provides custom Chemraz® elastomer and Arlon® high-temperature thermoplastic solutions. A combination of material performance and engineering design optimizes wafer handling. This enhances slip resistance, wear resistance, and low sticking properties.

CONDUCTOR ETCH SOLUTIONS



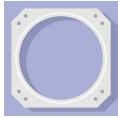
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



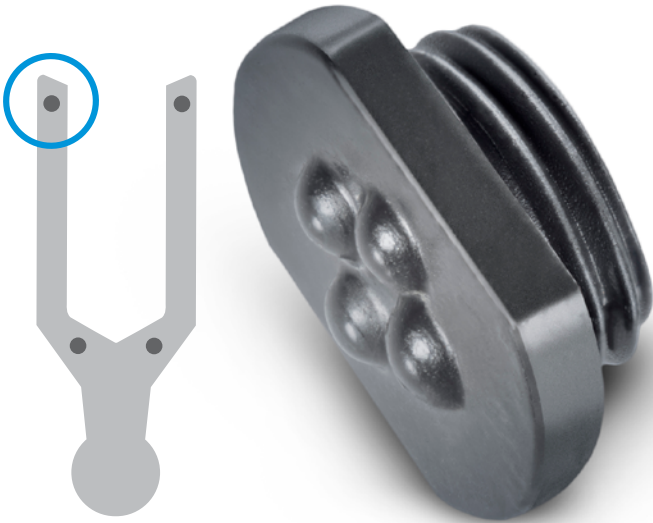
Chamber Seal Solutions



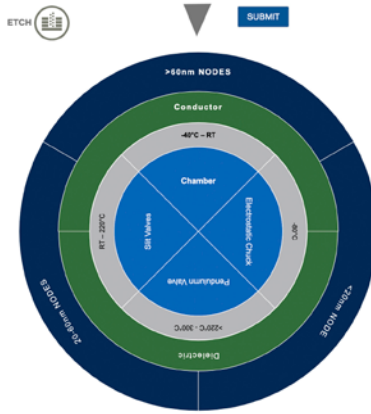
Pendulum Valve Solutions



Turbomolecular Pump Solutions



Arlon 3000XT® End-effector pad

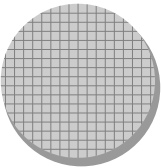


Click on the Elastomer Selection Wheel to explore other Chemraz® material options

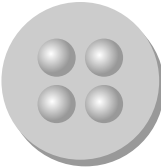
[Click on the compound for more information.](#)

Chemraz® XCD | Arlon® | Arlon 3000XT®

DESIGN SOLUTIONS



Custom Surface Finishes



Custom Surface Design



Extremely Small O-rings



Custom Bonded Designs



Custom Elastomer Pad Designs



Custom Plastic Pad Designs

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

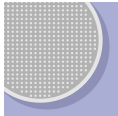
Chamber Seal Solutions

Chemraz® seals provide excellent performance in plasma etch processes. In particular they are compatible with fluorine and oxygen plasmas and are less susceptible to cracking. Seal design also needs to be considered to optimize seal performance.

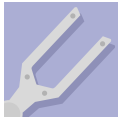
CONDUCTOR ETCH SOLUTIONS



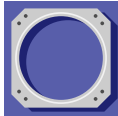
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



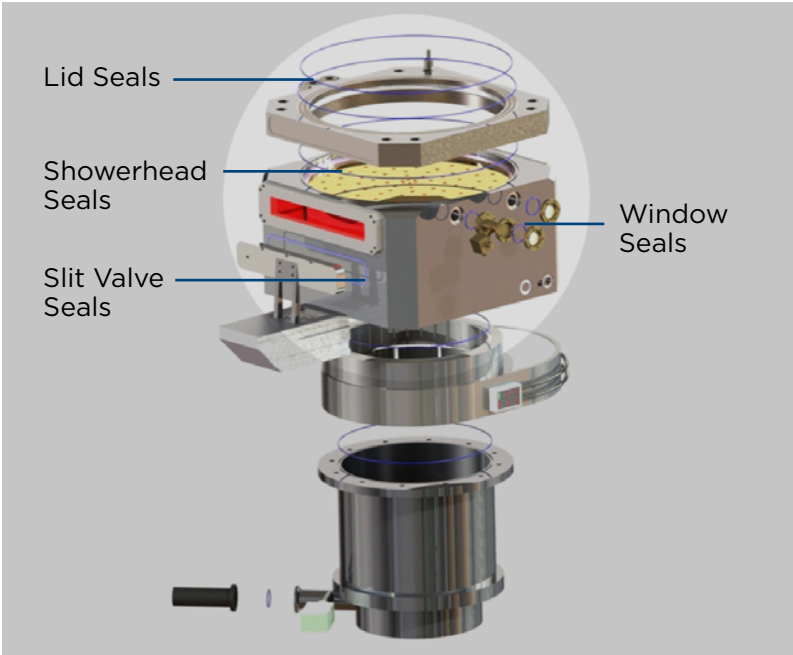
Chamber Seal Solutions



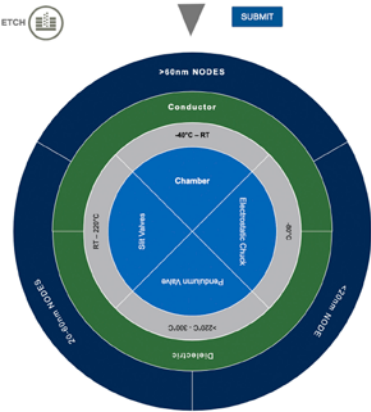
Pendulum Valve Solutions



Turbomolecular Pump Solutions



Typical process chamber.



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® G57 | Chemraz® XPE | Chemraz® 629
Chemraz® E38 | Chemraz® G38

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



Dovetail Seal
(Dovetail Gland)



Glandlock® Seal
(Half Dovetail Gland)



Formed Seal



Barrel Seal
(All Glands)



Shielded Seal
(All Glands)

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

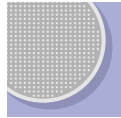
Turbomolecular Pump Solutions

Chemraz® and Fusion® solutions can be used in turbomolecular pump applications up to 300°C and are compatible with deposition and etch process gases such as fluorine and oxygen. The combination elastomer material and seal design provides solutions that are less susceptible to cracking and overfill.

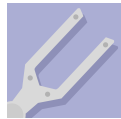
CONDUCTOR ETCH SOLUTIONS



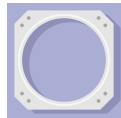
Slit Valve Solutions



Electrostatic Chuck Solutions



End Effector Solutions



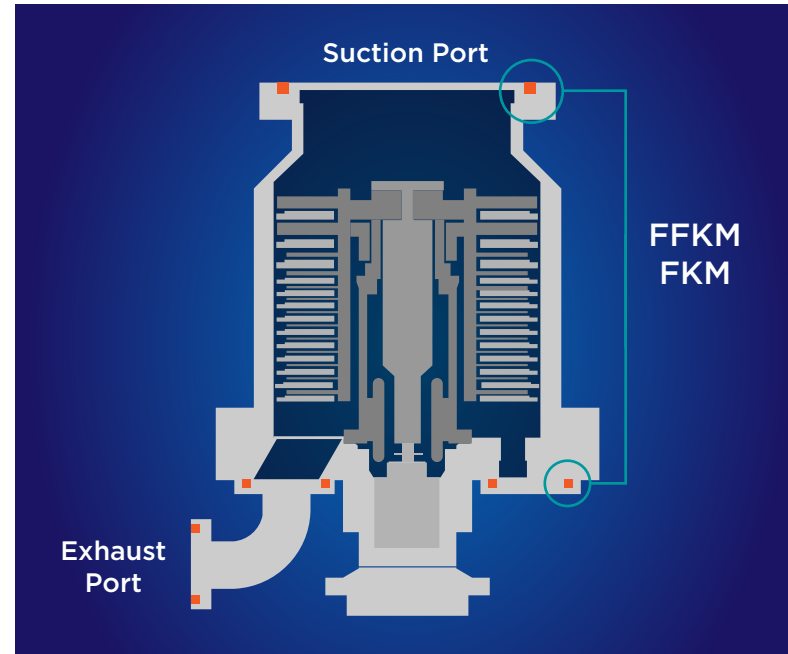
Chamber Seal Solutions



Pendulum Valve Solutions



Turbomolecular Pump Solutions



Seal locations on a turbomolecular pump

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



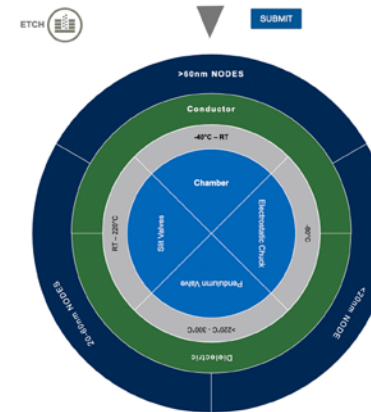
Custom Seal Design
(Glandlock® Seal)



Custom Design Seal
(Barrel Seal)



O-ring Kits



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® G38

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

ASH/STRIP SOLUTIONS

Our seals offer superior chemical resistance, minimal particle generation in plasma, and long service life to minimize maintenance and downtime.

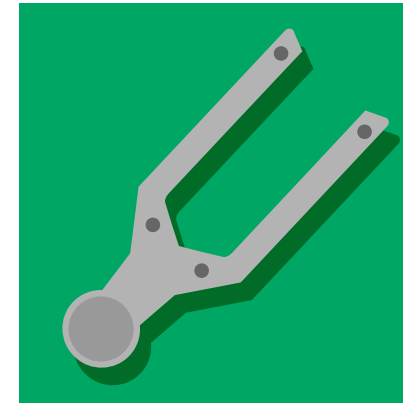
In ash/strip tools, seals are typically used in chambers, gas entry/exhaust ports, chamber doors, and wafer chucks. Protection against oxygen and hydrogen infused plasma is key in many ash/strip chamber environments, which often break down non-resistant materials and cause harmful particulation, resulting in defective chips.



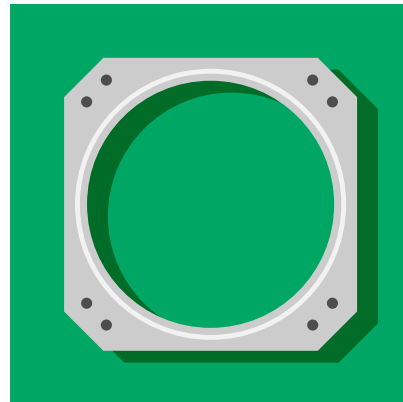
Slit Valve Solutions



Pendulum Valve Solutions



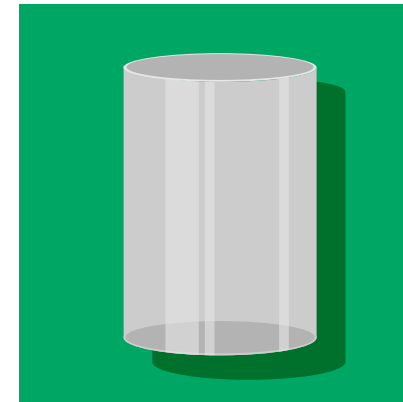
End Effector Solutions



Chamber Seal Solutions



Bell Jar Solutions



Plasma Tube Solutions

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Slit Valve Solutions

The Shielded-Bonded Slit Valve Door (SBSV) and Bonded Slit Valve Door (BSV) significantly increase the life expectancy and performance of the door's seal during semiconductor plasma processing. Made from Greene Tweed's proprietary high-purity PTFE compound, Avalon® 56 HP, the SBSV shield enhances our unique BSV (Bonded Slit Valve) door design.

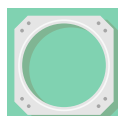
ASH/STRIP SOLUTIONS



Slit Valve Solutions

Pendulum
Valve
Solutions

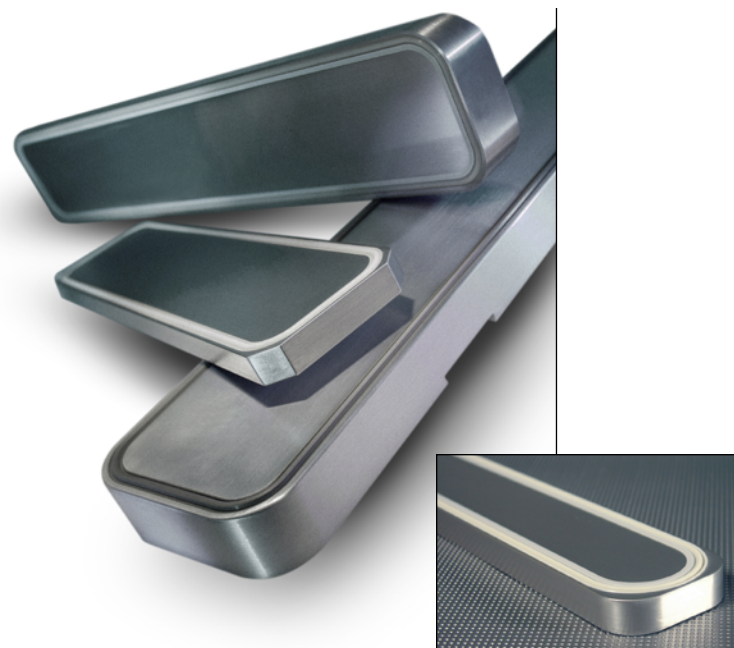
End Effector Solutions

Chamber Seal
Solutions

Bell Jar
Solutions



Plasma Tube Solutions



Bonded Slit Valve (BSV) Doors and
Shielded-Bonded Slit Valve (SBSV) Door (inset)

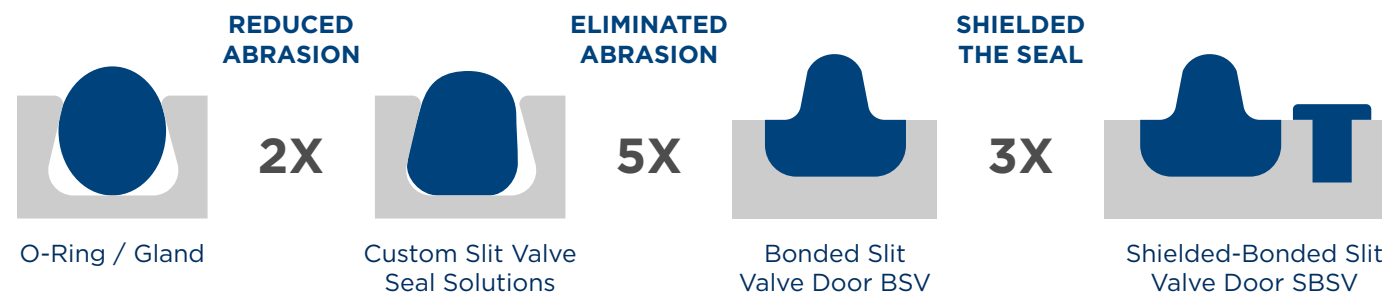


Click on the Elastomer Selection Wheel to explore other Chemraz® material options

Click on the compound for more information.

Chemraz® 629

SEAL DESIGN EVOLUTION



GREENE TWEED OVERVIEW

SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed
sealing solutions engineer
to learn how we can help solve
your application concerns.

Pendulum Valve Solutions

Our pendulum valve solutions significantly increase the life expectancy and performance of the gate valves during semiconductor plasma processing. These solutions are designed to eliminate premature failures caused by chemical and mechanical degradation.

ASH/STRIP SOLUTIONS



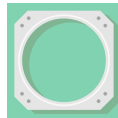
Slit Valve Solutions



Pendulum Valve Solutions



End Effector Solutions



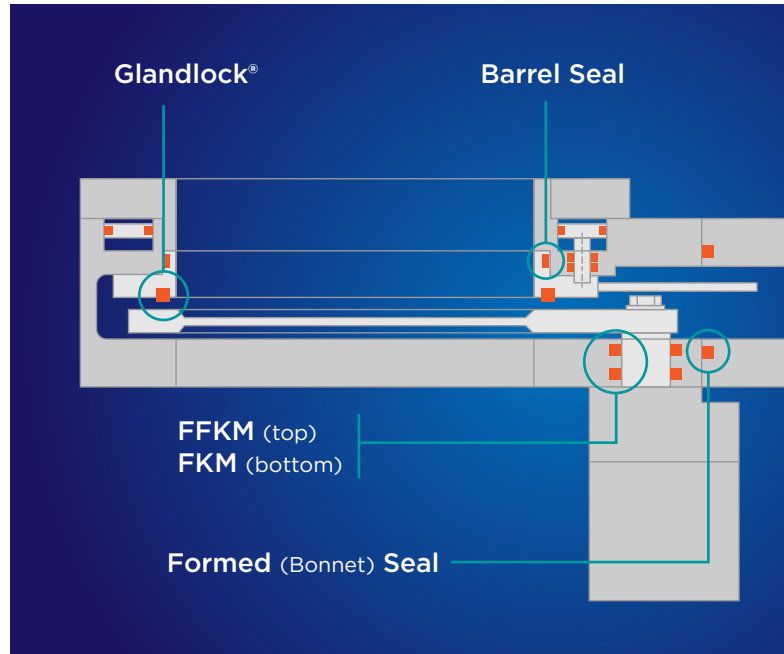
Chamber Seal Solutions



Bell Jar Solutions



Plasma Tube Solutions



Seal placement in the pendulum valve

SEAL DESIGN SOLUTIONS



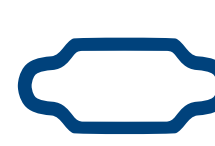
O-Ring
(Dynamic Actuator)



Glandlock® Seal
(Plate)



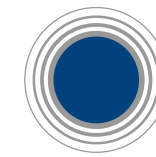
Barrel Seal
(Body)



Formed Seal
(Bonnet)



Bonded Seal
(Paddle)



Coated Seals
(Dynamic Actuator)



[Click on the compound for more information.](#)

Chemraz® 629

Click on the Elastomer Selection Wheel to explore other Chemraz® material options

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

Wafer Transfer Robot End-Effector Solutions

Greene Tweed offers end effector solutions (wafer handling/robot blade applications) including o-rings. Greene Tweed provides custom Chemraz® elastomer and Arlon® high-temperature thermoplastic solutions. A combination of material performance and engineering design optimizes wafer handling. This enhances slip resistance, wear resistance, and low sticking properties.

GREENE TWEED OVERVIEW
SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

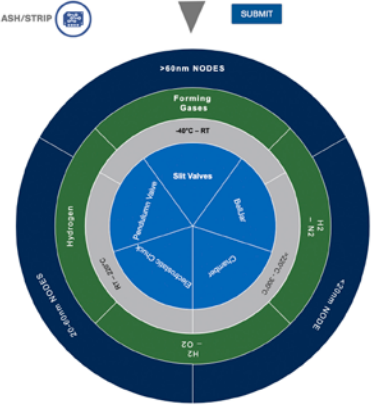
Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

Click on the Elastomer Selection Wheel to explore other Chemraz® material options



Click on the compound for more information.

Chemraz® XCD | Arlon® | Arlon 3000XT®

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

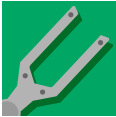
ASH/STRIP SOLUTIONS



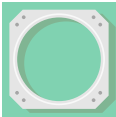
Slit Valve Solutions



Pendulum Valve Solutions



End Effector Solutions



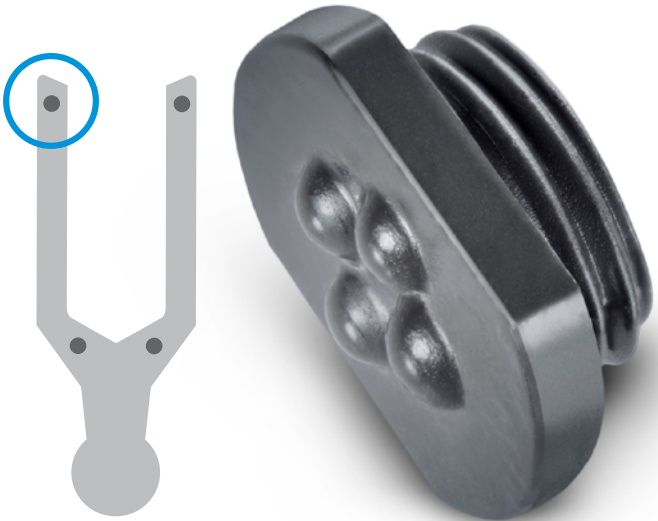
Chamber Seal Solutions



Bell Jar Solutions

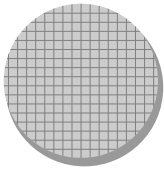


Plasma Tube Solutions

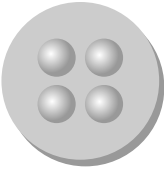


Arlon 3000XT® End-effector pad

DESIGN SOLUTIONS



Custom Surface Finishes



Custom Surface Design



Extremely Small O-rings



Custom Bonded Designs



Custom Elastomer Pad Designs



Custom Plastic Pad Designs

Chamber Seal Solutions

Chemraz® seals provide excellent performance in plasma etch processes. In particular they are compatible with fluorene and oxygen plasmas and are less susceptible to cracking. Seal design also needs to be considered to optimize seal performance.

ASH/STRIP SOLUTIONS



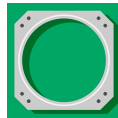
Slit Valve Solutions



Pendulum Valve Solutions



End Effector Solutions



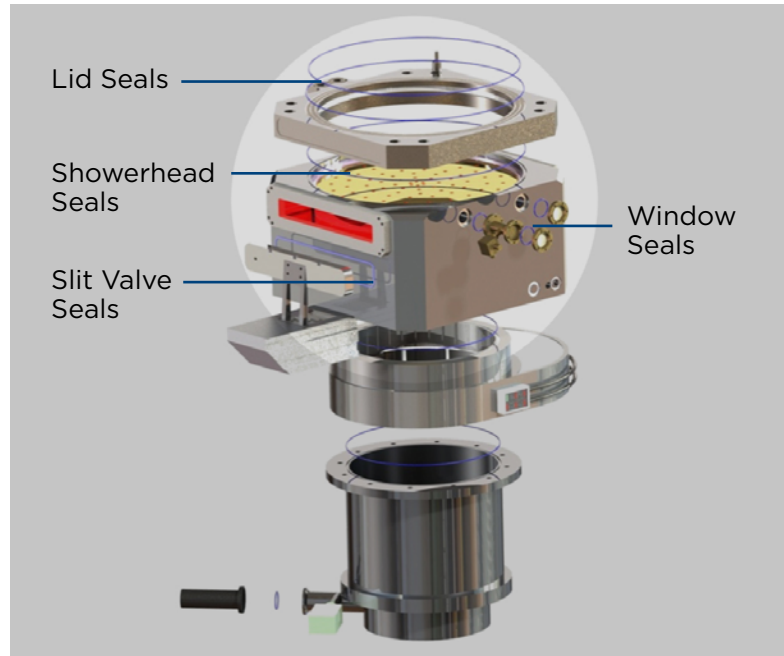
Chamber Seal Solutions



Bell Jar Solutions



Plasma Tube Solutions



Typical process chamber.



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® XPE | Chemraz® G57 | Chemraz® 629
Chemraz® E38 | Chemraz® G38

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



Dovetail Seal
(Dovetail Gland)



Glandlock® Seal
(Half Dovetail Gland)



Formed Seal



Barrel Seal
(All Glands)



Shielded Seal
(All Glands)

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

GREENE TWEED OVERVIEW
SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Bell Jar Solutions

Our bell jar/quartz sealing solutions significantly increase performance including life expectancy and particulation in this application. Custom Chemraz® and seal design optimize performance of the bell jar during semiconductor plasma processing. These solutions are designed to eliminate premature failures caused by chemical and mechanical degradation and prevent quartz to metal contact.

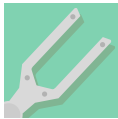
ASH/STRIP SOLUTIONS



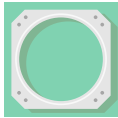
Slit Valve Solutions



Pendulum Valve Solutions



End Effector Solutions



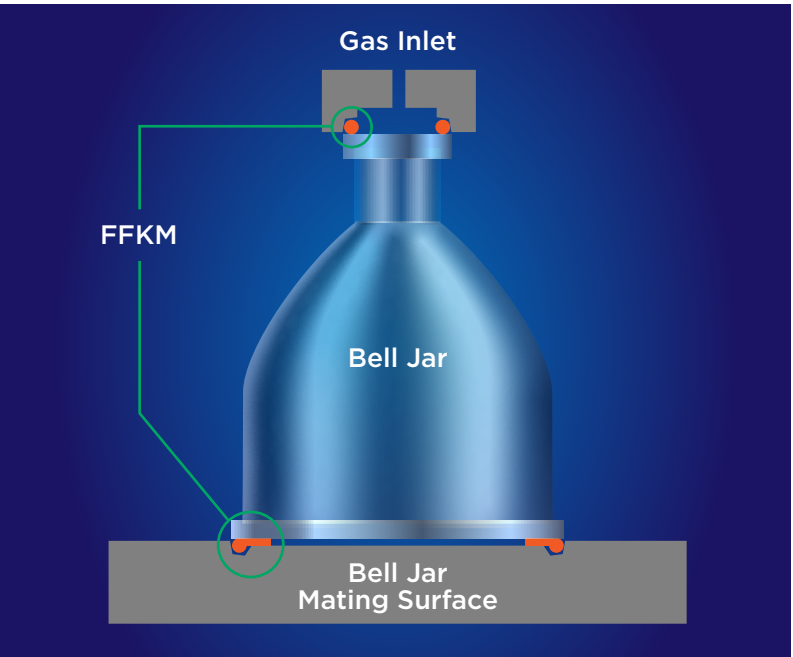
Chamber Seal Solutions



Bell Jar Solutions



Plasma Tube Solutions



Bell Jar application showing elastomer placement.

SEAL DESIGN SOLUTIONS



O-Ring



Custom Seal Design



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® 629

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

Plasma Tube Solutions

Our plasma tube solutions significantly increase life expectancy in this application. Custom Chemraz® and seal design optimize performance including high-temperature capability, reduced mechanical stress, and less sticking. Shielded designs also extend life expectancy in this application. Typical shield materials include Aluminum 6061-T6 and Avalon® 56 HP.

ASH/STRIP SOLUTIONS



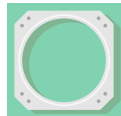
Slit Valve Solutions



Pendulum Valve Solutions



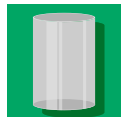
End Effector Solutions



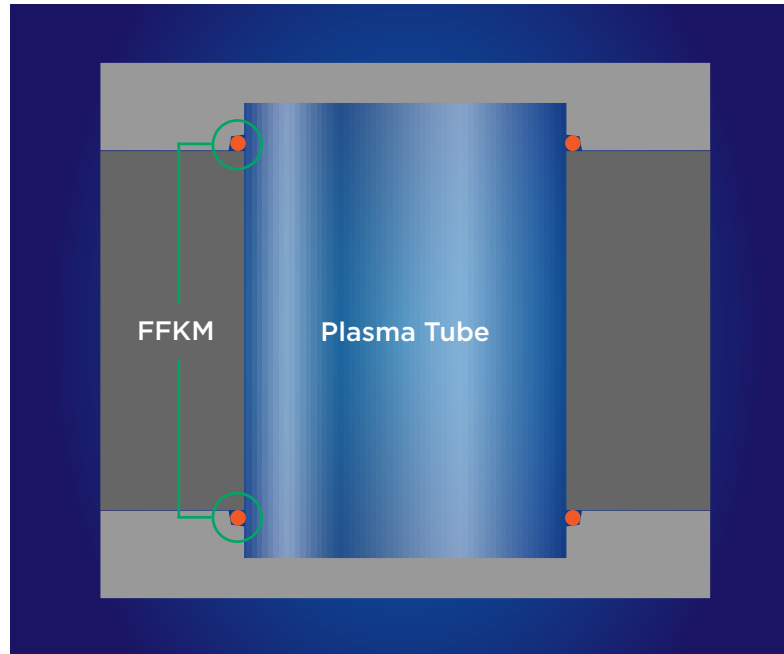
Chamber Seal Solutions



Bell Jar Solutions



Plasma Tube Solutions



Plasma tube with seal placement.

SEAL DESIGN SOLUTIONS



O-Ring



Custom Seal Designs



Shielded Seal Design



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® XRZ

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

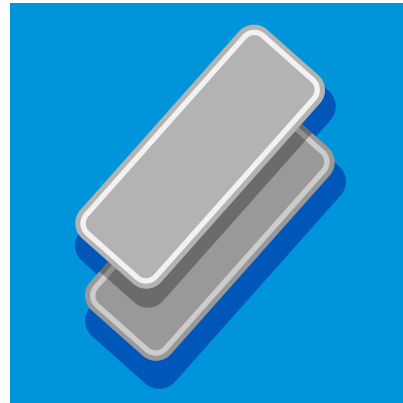
Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

In CVD tools, seals are typically used in chambers, gas entry/exhaust ports, chamber doors, and wafer chucks. Protection against oxygen and fluorine infused plasma is key in many CVD chamber environments, which often break down non-resistant materials and cause harmful particulation, resulting in defective chips.

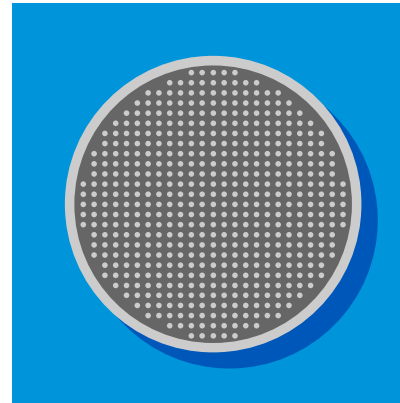
PECVD/PEALD SOLUTIONS

PLASMA ENHANCED
CHEMICAL VAPOR DEPOSITION
AND ATOMIC LAYER
DEPOSITION SOLUTIONS

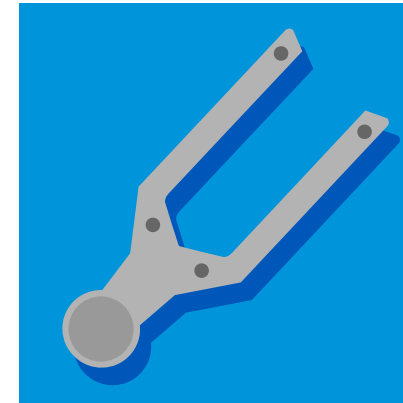
Our seals offer superior chemical resistance, minimal particle generation in plasma, and long service life to minimize maintenance and downtime.



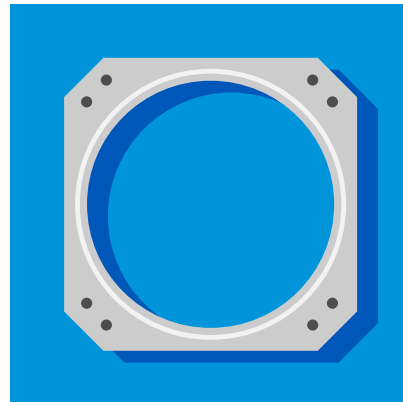
Slit Valve Solutions



E-Seal Solutions



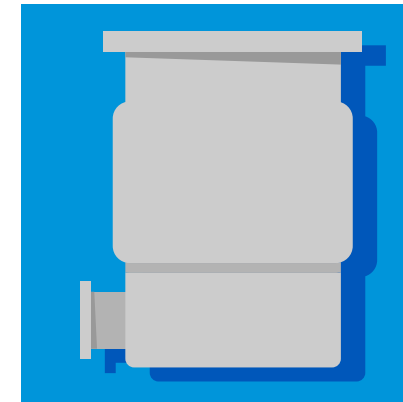
End Effector Solutions



Chamber Seal Solutions



Pendulum Valve Solutions



Turbomolecular Pump Solutions

GREENE TWEED OVERVIEW

SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

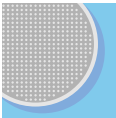
Slit Valve Solutions

The Shielded-Bonded Slit Valve Door (SBSV) and Bonded Slit Valve Door (BSV) significantly increase the life expectancy and performance of the door's seal during semiconductor plasma processing. Made from Greene Tweed's proprietary high-purity PTFE compound, Avalon® 56 HP, the SBSV shield enhances our unique BSV (Bonded Slit Valve) door design.

PECVD/PEALD SOLUTIONS PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION AND ATOMIC LAYER DEPOSITION SOLUTIONS



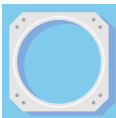
Slit Valve
Solutions



Electrostatic
Chuck
Solutions



End Effector
Solutions



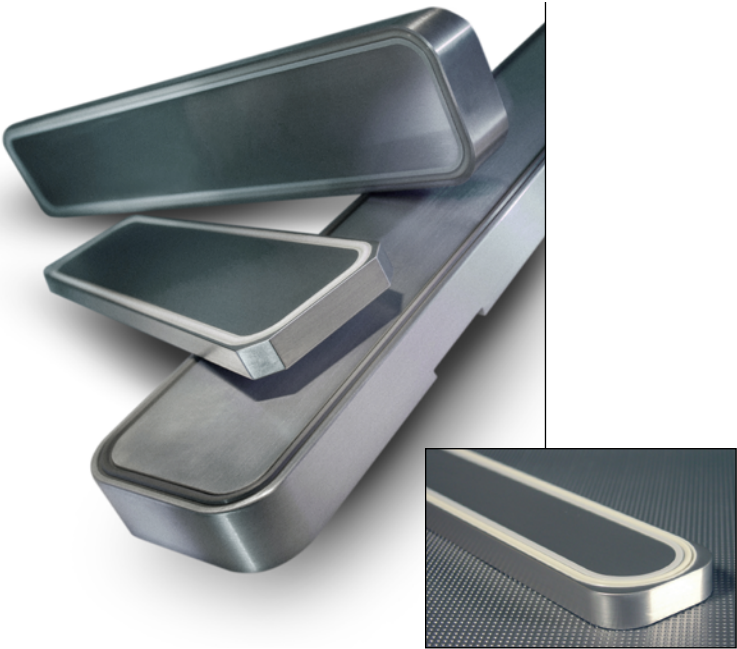
Chamber Seal
Solutions



Pendulum
Valve
Solutions



Turbomolecular
Pump
Solutions



Bonded Slit Valve (BSV) Doors and
Shielded-Bonded Slit Valve (SBSV) Door (inset)

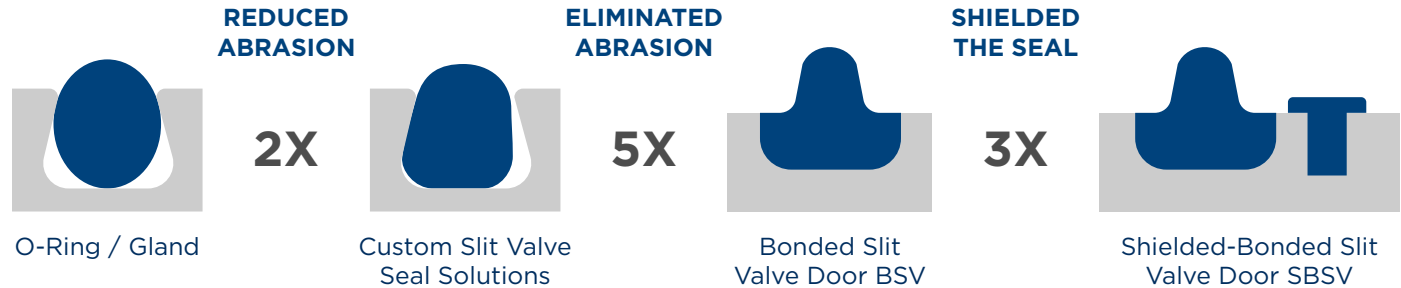


Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

[Click on the compound for more information.](#)

Chemraz® XRZ | Chemraz® G20 | Chemraz® 629
Chemraz® G13

SEAL DESIGN EVOLUTION



GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

Contact a Greene Tweed
sealing solutions engineer
to learn how we can help solve
your application concerns.

Electrostatic Chuck (ESC) Solutions

E-seal refers to the electrostatic chuck seal application. Made from Greene Tweed’s proprietary high-purity Chemraz® elastomers and Avalon® 56 HP PTFE fluoroplastics compounds, the e-seal significantly increases the life expectancy of the electrostatic chuck by protecting the outside diameter of the chuck from plasma erosion. To enable extreme cooling of the e-chuck, Greene Tweed provides custom MSE cryogenic seals that seal down to -150°C. Chemraz® 663 allows sealing down to -40°C.

PECVD/PEALD SOLUTIONS PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION AND ATOMIC LAYER DEPOSITION SOLUTIONS



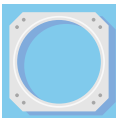
Slit Valve
Solutions



**Electrostatic
Chuck
Solutions**



End Effector
Solutions



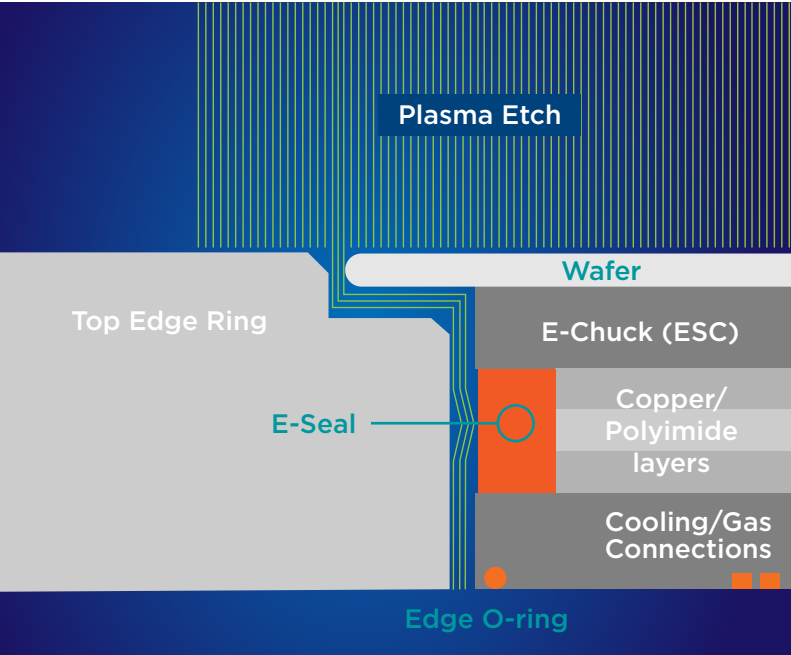
Chamber Seal
Solutions



Pendulum
Valve
Solutions



Turbomolecular
Pump
Solutions



E-Seal solution to protect the E-Chuck



Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

[Click on the compound for more information.](#)

Chemraz® XPE | Chemraz® 663 | Chemraz® 629
Avalon® 56 HP | MSE® Cryogenic

SEAL DESIGN SOLUTIONS Small cross-sections, critical, high-precision



O-Ring
(All Glands)



Elastomer
(All Glands)



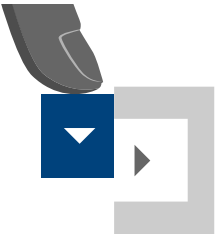
Plastic
(All Glands)



Plastic Encapsulated
O-ring
(All Glands)



MSE (low temp)
(All Glands)



Installation
Fixtures

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

Related Videos

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sealing solutions engineer
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your application concerns.

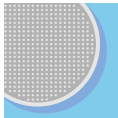
Wafer Transfer Robot End-Effector Solutions

Greene Tweed offers end effector solutions (wafer handling/robot blade applications) including o-rings. Greene Tweed provides custom Chemraz® elastomer and Arlon® high-temperature thermoplastic solutions. A combination of material performance and engineering design optimizes wafer handling. This enhances slip resistance, wear resistance, and low sticking properties.

PECVD/PEALD SOLUTIONS PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION AND ATOMIC LAYER DEPOSITION SOLUTIONS



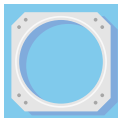
Slit Valve
Solutions



Electrostatic
Chuck
Solutions



**End Effector
Solutions**



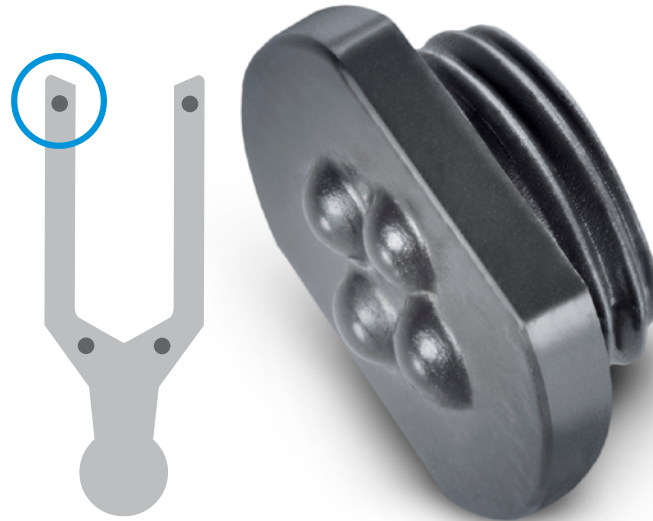
Chamber Seal
Solutions



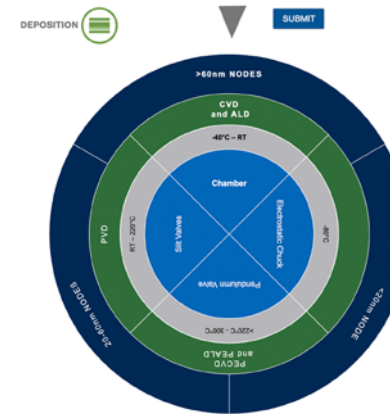
Pendulum
Valve
Solutions



Turbomolecular
Pump
Solutions



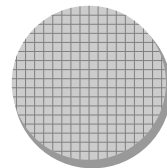
Arlon 3000XT® End-effector pad



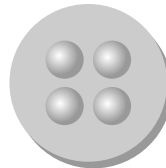
[Click on the compound for more information.](#)

Chemraz® XCD | Arlon® | Arlon 3000XT®

DESIGN SOLUTIONS



Custom
Surface
Finishes



Custom
Surface
Design



Extremely
Small O-rings



Custom Bonded
Designs



Custom Elastomer
Pad Designs



Custom Plastic
Pad Designs

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

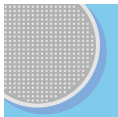
Chamber Seal Solutions

Chemraz® seals provide excellent performance in plasma etch processes. In particular they are compatible with fluorene and oxygen plasmas and are less susceptible to cracking. Seal design also needs to be considered to optimize seal performance.

PECVD/PEALD SOLUTIONS PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION AND ATOMIC LAYER DEPOSITION SOLUTIONS



Slit Valve
Solutions



Electrostatic
Chuck
Solutions



End Effector
Solutions



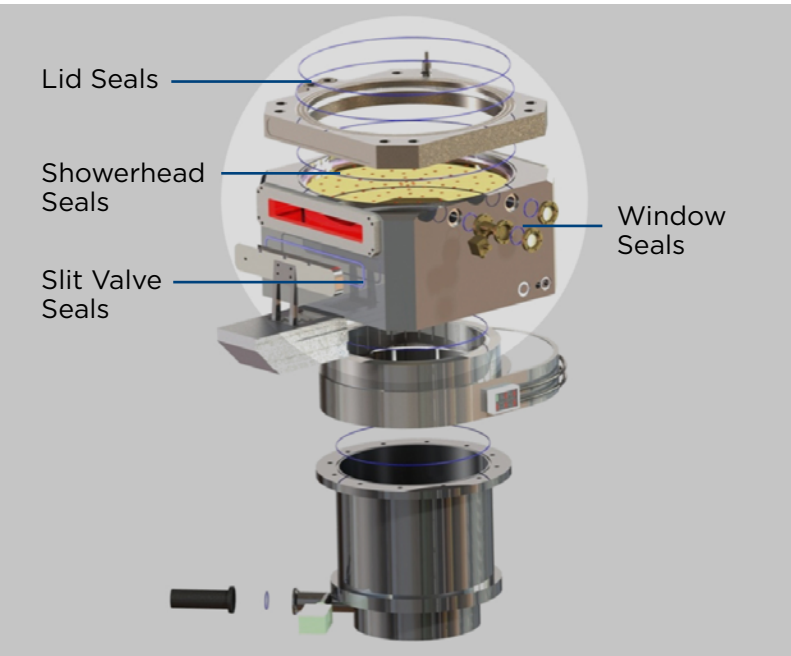
**Chamber Seal
Solutions**



Pendulum
Valve
Solutions



Turbomolecular
Pump
Solutions



Typical process chamber.



Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

[Click on the compound for more information.](#)

Chemraz® XRZ | Chemraz® G20 | Chemraz® 629
Chemraz® G13 | Enduro® LF10

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



Dovetail Seal
(Dovetail Gland)



Glandlock® Seal
(Half Dovetail Gland)



Formed Seal



Barrel Seal
(All Glands)



Shielded Seal
(All Glands)

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

Contact a Greene Tweed
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your application concerns.

Pendulum Valve Solutions

Our pendulum valve solutions significantly increase the life expectancy and performance of the gate valves during semiconductor plasma processing. These solutions are designed to eliminate premature failures caused by chemical and mechanical degradation.

PECVD/PEALD SOLUTIONS PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION AND ATOMIC LAYER DEPOSITION SOLUTIONS



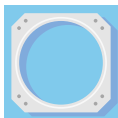
Slit Valve
Solutions



Electrostatic
Chuck
Solutions



End Effector
Solutions



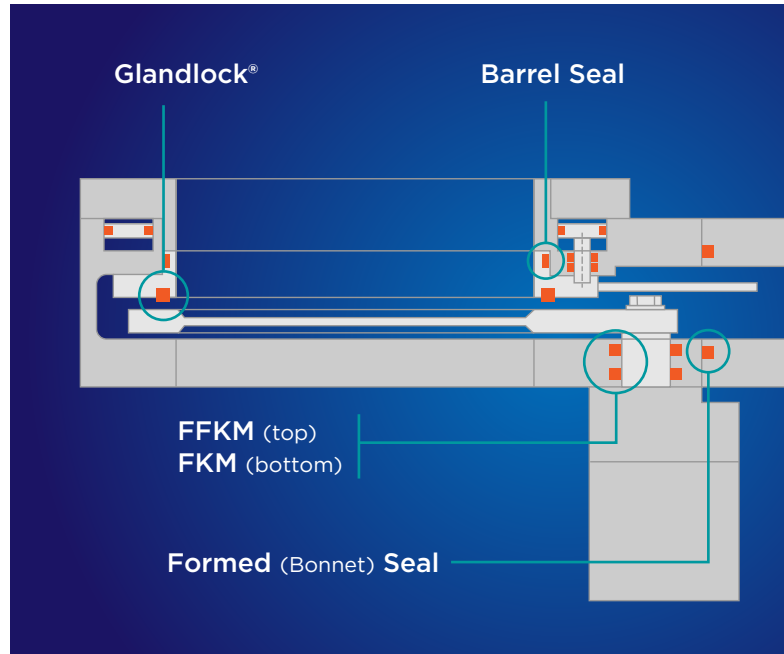
Chamber Seal
Solutions



**Pendulum
Valve
Solutions**



Turbomolecular
Pump
Solutions



Seal placement in the pendulum valve

SEAL DESIGN SOLUTIONS



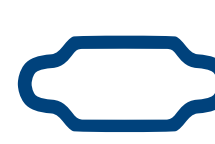
O-Ring
(Dynamic Actuator)



Glandlock® Seal
(Plate)



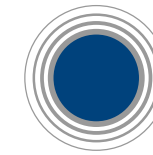
Barrel Seal
(Body)



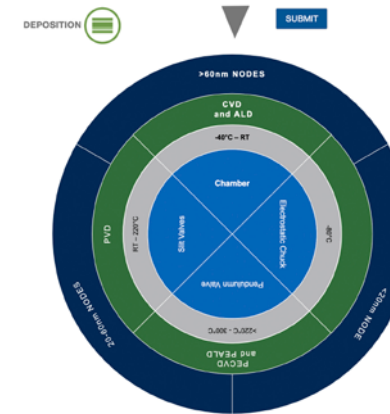
Formed Seal
(Bonnet)



Bonded Seal
(Paddle)



Coated Seals
(Dynamic Actuator)



Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

[Click on the compound for more information.](#)

Chemraz® XRZ | Chemraz® G20 | Chemraz® 629

Chemraz® G13 | Enduro® LF10

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

**Seal Handling
Training**

**Chemical
Compatibility
Guide**

Contact a Greene Tweed
sealing solutions engineer
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your application concerns.

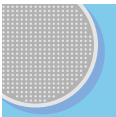
Turbomolecular Pump Solutions

Chemraz® and Fusion® solutions can be used in turbomolecular pump applications up to 300°C and are compatible with deposition and etch process gases such as fluorine and oxygen. The combination elastomer material and seal design provides solutions that are less susceptible to cracking and overfill.

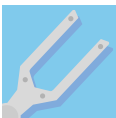
PECVD/PEALD SOLUTIONS PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION AND ATOMIC LAYER DEPOSITION SOLUTIONS



Slit Valve
Solutions



Electrostatic
Chuck
Solutions



End Effector
Solutions



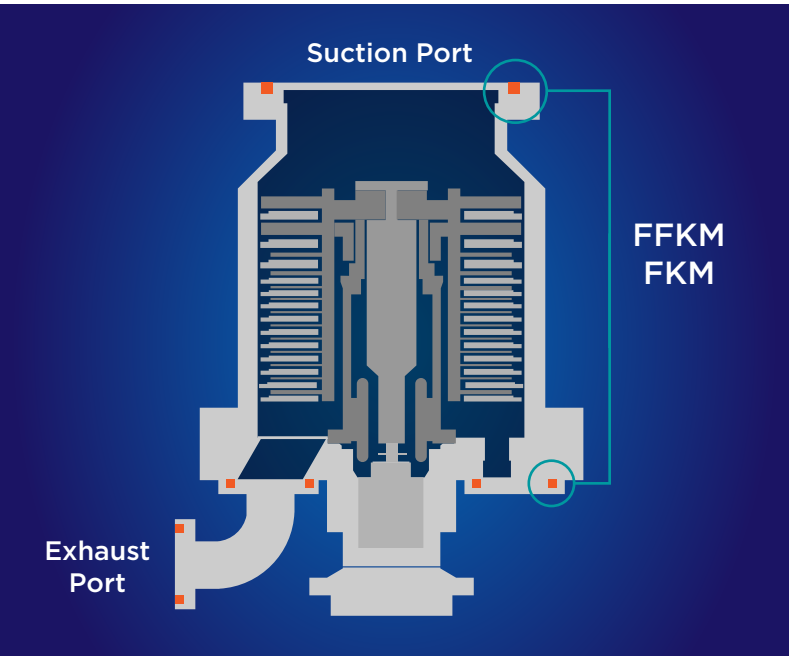
Chamber Seal
Solutions



Pendulum
Valve
Solutions



**Turbomolecular
Pump
Solutions**



Seal locations on a turbomolecular pump

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



Custom Seal Design
(Glandlock® Seal)



Custom Design Seal
(Barrel Seal)



O-ring Kits



Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

[Click on the compound for more information.](#)

Chemraz® G20

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

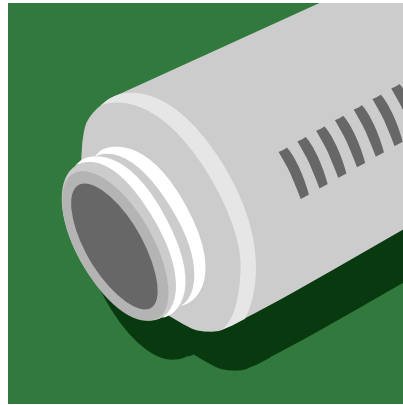
Contact a Greene Tweed
sealing solutions engineer
to learn how we can help solve
your application concerns.

WET PROCESSING SOLUTIONS

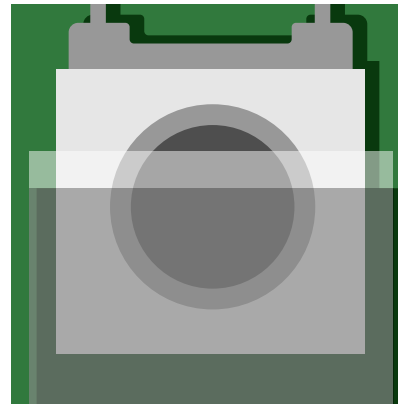
DI WATER
WET ETCH
WAFER CLEANS

Our seals offer superior chemical resistance, minimal particle generation in plasma, and long service life to minimize maintenance and downtime.

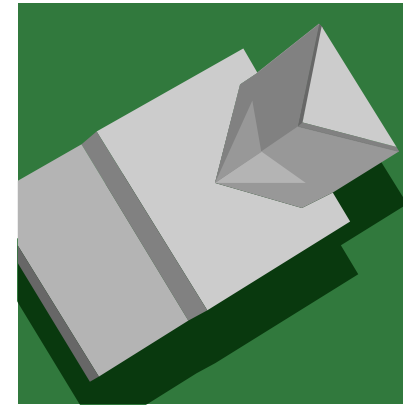
In wet wafer processing tools, seals are typically used in wet chambers, electroplating, filter cartridges, and chillers. Sealing against a wide variety of chemistries including, acids, DI water, and electroplating solutions. High material compatibility and purity ensures cleanliness in the systems.



Filter Cartridge Seals



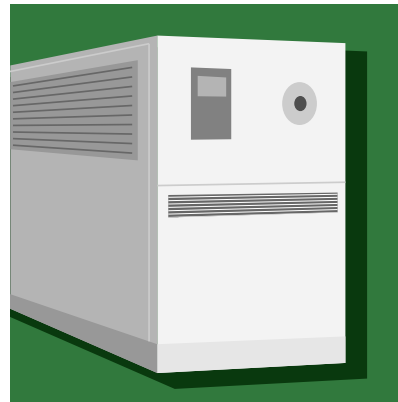
Electroplating



Engineered Components



Wet Chamber Seal Solutions



Chillers

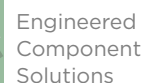
ADDITIONAL RESOURCES

Seal Handling Training

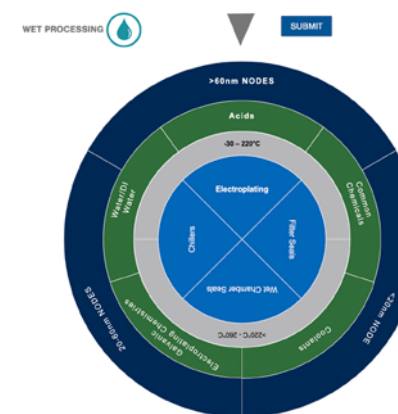
Chemical Compatibility Guide

WET PROCESSING SOLUTIONS

DI WATER WET ETCH WAFER CLEANS



Seal placement on a filter cartridge



Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

Click on the compound for more information.

Chemraz® 551 | Chemraz® 570

UltraClean Chemraz® post cleaning process

SEAL DESIGN SOLUTIONS



Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

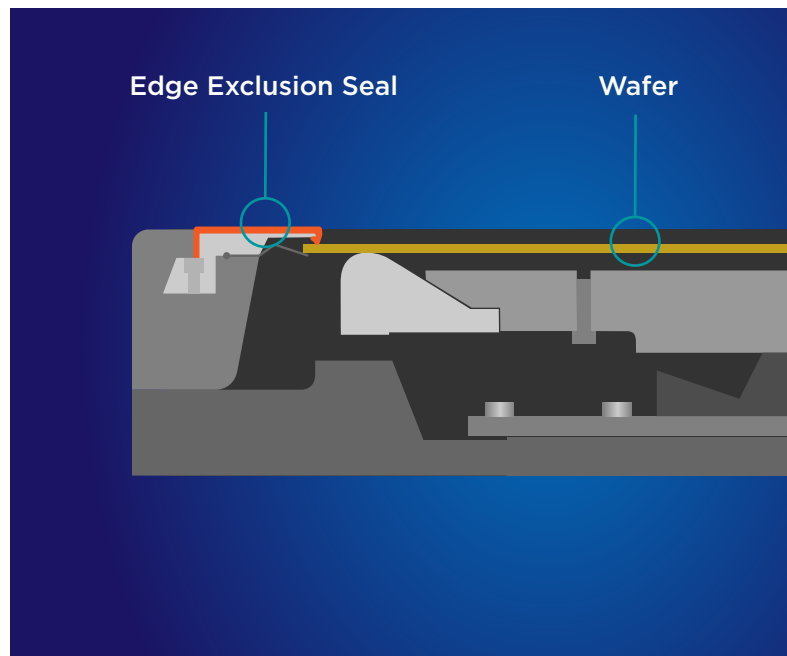
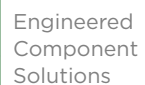
Seal Handling Training

Chemical Compatibility Guide

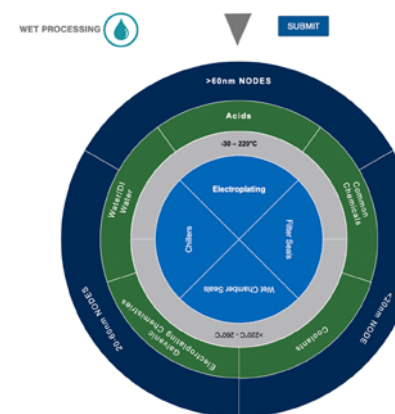
Contact a Greene Tweed
sealing solutions engineer
to learn how we can help solve
your application concerns.

Chemraz® seals provide excellent performance in electroplating chemistries. These include, WLP—wafer level packaging, TSV—thru silicon via, and BEOL—back end of line—interconnect applications and processes at temperature of 200°C or more. Enduro® coatings extend seal life by allowing effective part cleaning and resisting plate-up on seal surfaces.

DI WATER WET ETCH WAFER CLEANS



Typical process chamber.



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

SEAL DESIGN SOLUTIONS



ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed
sealing solutions engineer
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your application concerns.

Engineered Component Solutions

Engineered component solutions include custom designed and make to print chamber components like wafer holders, pins or screws. Materials highlighted are: Avalon® 56 HP & ONX® 600.

Avalon® fluoroplastic grades provide excellent purity and chemical compatibility. Precision components made from Avalon® 56 HP versus standard PTFE can increase component service life.

ONX® 600 fluoroplastic composites can be useful in a range of applications offering benefits such as excellent mechanical strength, ESD protection in aggressive conditions, high purity and chemical resistance. Large diameter disks are available for ONX® 600 (capability up to 508mm) as well as turnkey manufactured components.

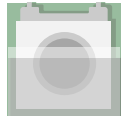
In addition to providing low ion contamination and low metal extractables, these engineered thermoplastic and composite solutions enhance overall tool performance.

WET PROCESSING SOLUTIONS

DI WATER
WET ETCH
WAFER CLEANS



Filter Cartridge
Seals



Electroplating
Seal Solutions



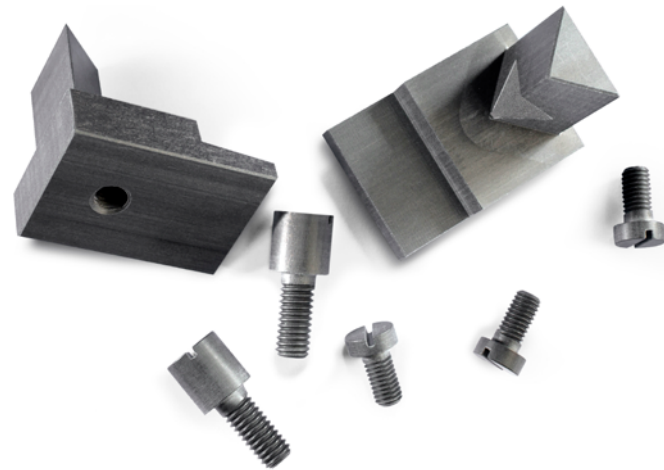
Engineered
Component
Solutions



Wet Chamber
Seal Solutions

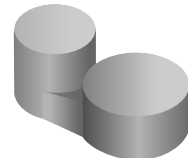


Chillers

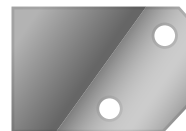


ONX® 600 wafer chucks and screws

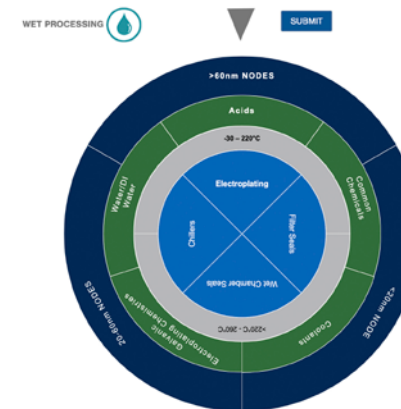
DESIGN SOLUTIONS



Wafer Holder
Chuck



Chamber
Component



Click on the
Elastomer
Selection
Wheel to
explore other
Chemraz®
material
options

[Click on the compound for more information.](#)

Avalon® 56 HP | ONX® 600

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

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Training

Chemical
Compatibility
Guide

Contact a Greene Tweed
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your application concerns.

Wet Chamber Seal Solutions

Chemraz® seals provide excellent performance in wet chemistries. In particular they are compatible with water, wet etch, and wafer clean chemistries and can handle these processes at high temperatures of 200°C or more. Chemraz seals show low TOCs, low leachable trace metals, and low ionic contamination in wet processing environments. Chemraz materials have excellent resistance in these applications.

WET PROCESSING SOLUTIONS

DI WATER
WET ETCH
WAFER CLEANS



Filter Cartridge
Seals



Electroplating
Seal Solutions



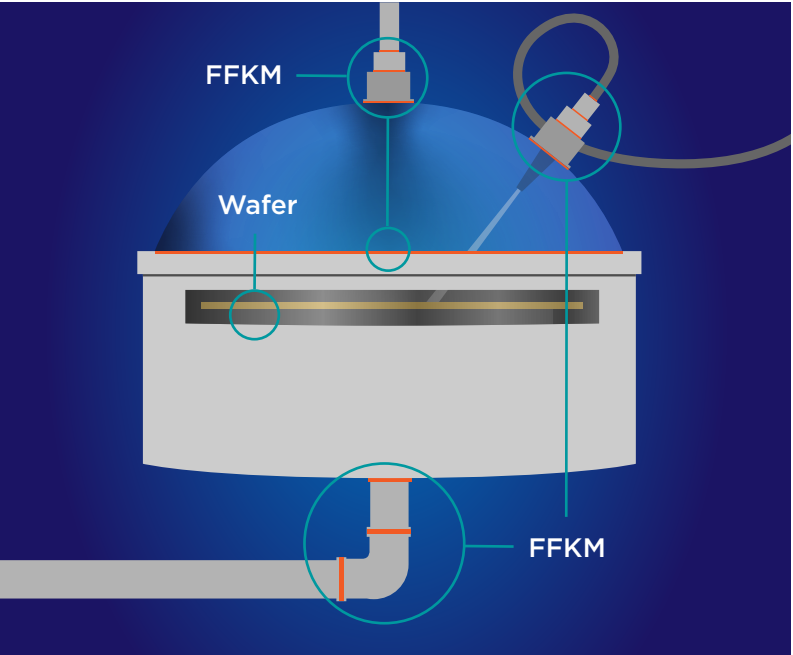
Engineered
Component
Solutions



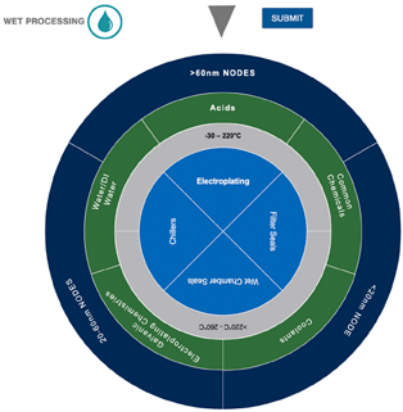
Wet Chamber
Seal Solutions



Chillers



Wet etch, wet clean chambers.



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® 551 | Chemraz® 570

UltraClean Chemraz® post cleaning process

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



Custom Seals
(All Gland)



Plastic Encapsulated
O-ring
(All Glands)

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling
Training

Chemical
Compatibility
Guide

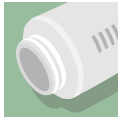
Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

Chiller Seal Solutions

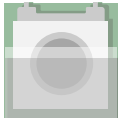
Chemraz® seals provide excellent performance in heat exchange systems including chillers. In particular they are compatible with water, heat exchange fluids, and coolants. This includes ethylene glycol and fluorinated coolants. Chemraz® can handle processes at high temperatures of 200°C or more.

WET PROCESSING SOLUTIONS

DI WATER
WET ETCH
WAFER CLEANS



Filter Cartridge
Seals



Electroplating
Seal Solutions



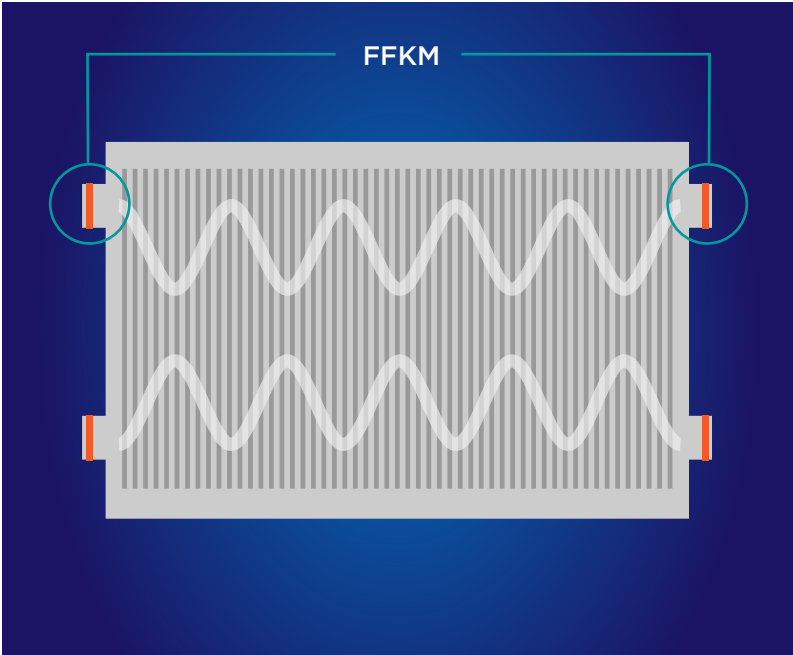
Engineered
Component
Solutions



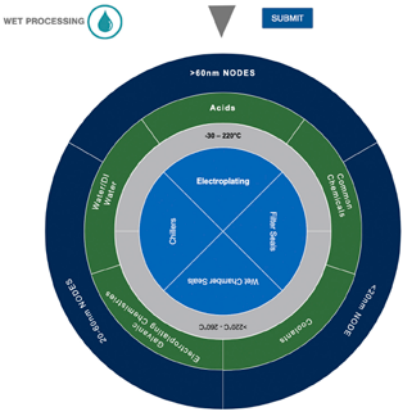
Wet Chamber
Seal Solutions



Chillers



Heat exchanger



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® 551 | Chemraz® 570

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



Custom Seals
(All Gland)



Plastic Encapsulated
O-ring
(All Glands)

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

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SubFab

ADDITIONAL RESOURCES

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Chemical
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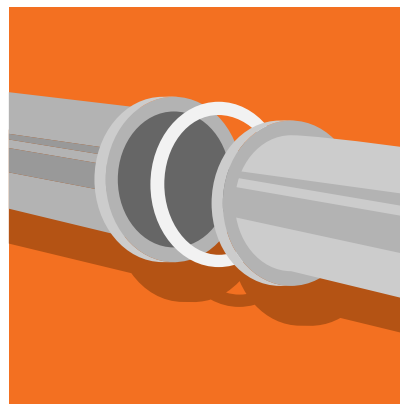
Chemraz® SubFab is a first-to-market total sealing solution that is specifically designed to withstand the highly corrosive environments that are commonly seen in today's SubFab applications.

SUBFAB SOLUTIONS

Complex chemistries in semiconductor processes require robust seals in the SubFab

Greene Tweed's Chemraz® sealing solutions can provide customers the following benefits:

- Increased MTBR (mean time between replacement)
- Improved reliability
- Enhanced repeatability
- Maximum system uptime
- Lower cost of ownership



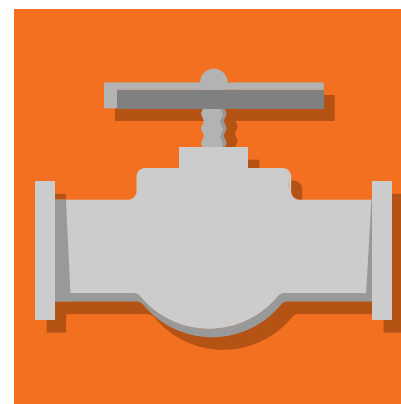
Vacuum Line Solutions



Pump Solutions



Abatement Solutions



Gate Valve Solutions

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

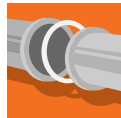
Seal Handling
Training

Chemical
Compatibility
Guide

Vacuum Line Solutions

As shown in the graphic below, Chemraz® solutions can be used in vacuum line applications up to 300°C and are compatible with deposition and etch process exhaust (fluorene and oxygen). Greene Tweed also offers Aluminum 6061-T6 and stainless steel kits in this application.

SUBFAB SOLUTIONS



Vacuum Line Solutions



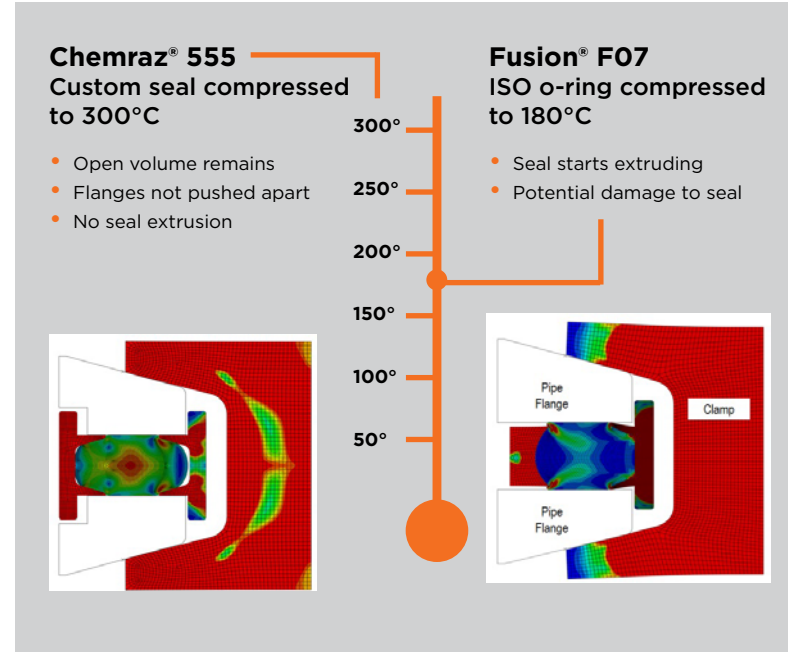
Pump Solutions



Abatement Solutions



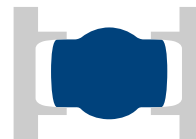
Gate Valve Solutions



SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



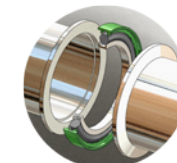
KF Custom Seals
(High Temp)



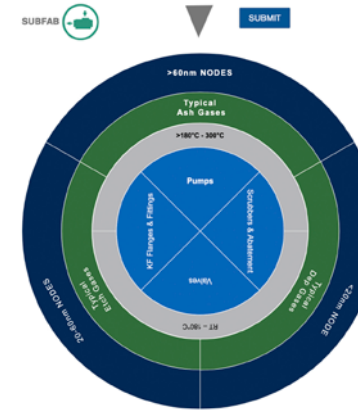
KF Standard and Custom O-ring



O-ring Kits



Custom Kits
(All components in one kit)



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® 555 | Fusion® F07

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

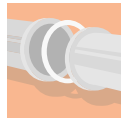
Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

Pump Solutions

Chemraz® solutions can be used in vacuum pump applications up to 300°C and are compatible with deposition and etch process exhaust gases such as fluorine and oxygen. They are also compatible with fluorinated lubricants commonly used in semiconductor rough pumping applications.

SUBFAB SOLUTIONS



Vacuum Line Solutions



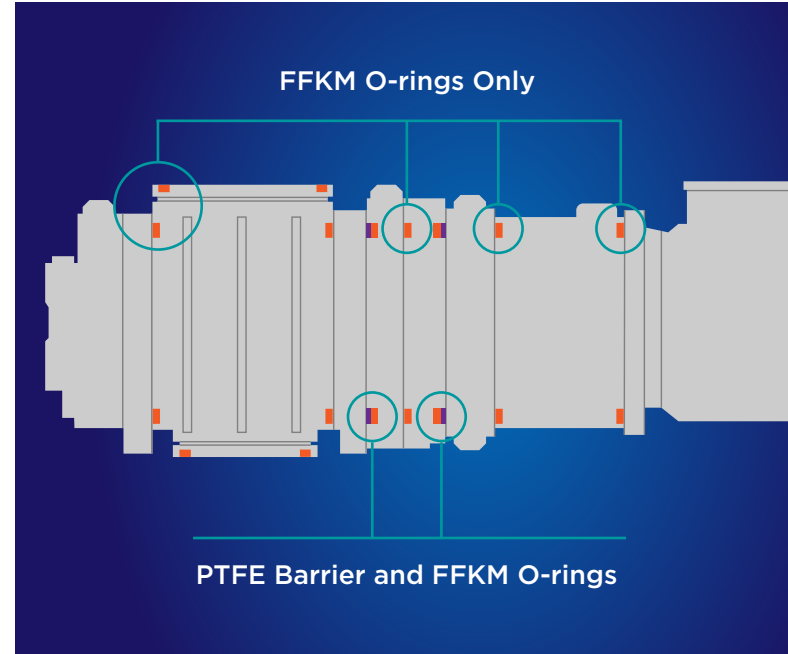
Pump Solutions



Abatement Solutions



Gate Valve Solutions



Seals within a EH mechanical booster pump

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



O-ring Kits



Custom Seal Design
(Scroll Seal)



Shielded Seal
(All Glands)



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

[Click on the compound for more information.](#)

Chemraz® 555 | Fusion® F07

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed sealing solutions engineer to learn how we can help solve your application concerns.

Abatement Solutions

Chemraz® solutions can be used in thermal abatement applications up to 300°C and are compatible with deposition and etch process exhaust gases such as fluorine and oxygen. They also have high resistance to water vapor and residual acids formed by the abatement process.

SUBFAB SOLUTIONS



Vacuum Line Solutions



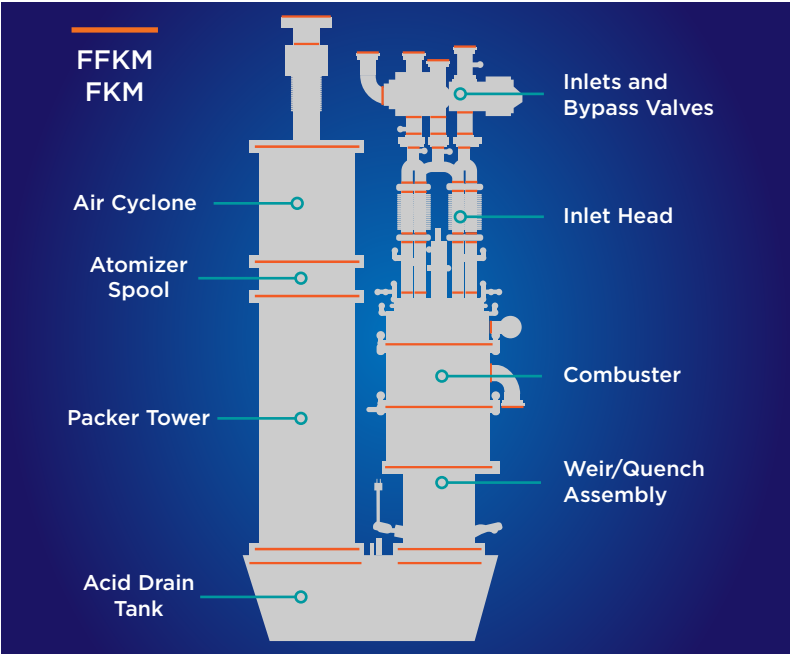
Pump Solutions



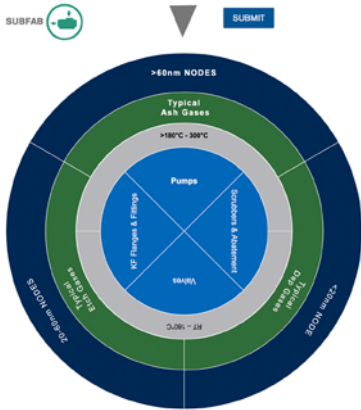
Abatement Solutions



Gate Valve Solutions



Abatement system components and seal locations



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

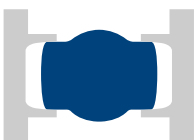
[Click on the compound for more information.](#)

Chemraz® 555 | Fusion® F07

SEAL DESIGN SOLUTIONS



O-Ring
(All Glands)



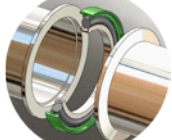
KF Custom Seals
(High Temp)



KF Standard and Custom O-ring



O-ring Kits



Custom Kits
(All components in one kit)

GREENE TWEED OVERVIEW SOLUTIONS BY PROCESS AREA

Dielectric Etch

Conductor Etch

Ash/Strip

PECVD/PEALD

Wet Processing

SubFab

ADDITIONAL RESOURCES

Seal Handling Training

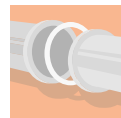
Chemical Compatibility Guide

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Gate Valve Solutions

Chemraz® and Fusion® materials are compatible with deposition and etch process exhaust gases such as fluorine and oxygen and deliver cost of ownership and reliability.

SUBFAB SOLUTIONS



Vacuum Line Solutions



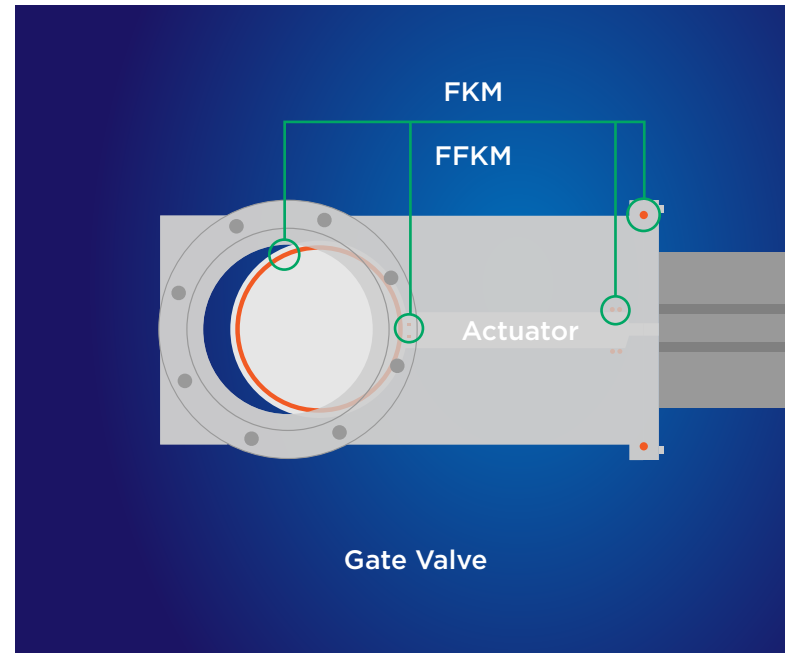
Pump Solutions



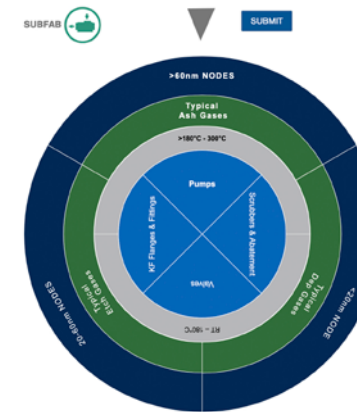
Abatement Solutions



Gate Valve Solutions



Elastomer locations on a gate valve



Click on the Elastomer Selection Wheel to explore other Chemraz® material options

Click on the compound for more information.

Chemraz® 555 | Fusion® F07

SEAL DESIGN SOLUTIONS



O-Ring
(Plate/Bonnet)



Custom Seals (Plate)



Formed Seal
(Bonnet)

ADDITIONAL RESOURCES

Seal Handling Training

Chemical Compatibility Guide

Contact a Greene Tweed
sealing solutions engineer
to learn how we can help solve
your application concerns.



gtweed.com

Greene Tweed

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